

EC-Lab[®] Express Software: Techniques and Applications

Version 5.5x – November 2011



Equipment installation

WARNING! The instrument is safely grounded to the Earth through the protective conductor of the AC power cable.

Use only the power cord supplied with the instrument and designed for the good current rating (10 Amax) and be sure to connect it to a power source provided with protective earth contact.

Any interruption of the protective earth (grounding) conductor outside the instrument could result in personal injury.

Please consult the installation manual for details on the installation of the instrument.

General description

The equipment described in this manual has been designed in accordance with EN61010 and EN61326 and has been supplied in a safe condition. The equipment is intended for electrical measurements only. It should be used for no other purpose.

Intended use of the equipment

This equipment is an electrical laboratory equipment intended for professional and intended to be used in laboratories, commercial and light-industrial environments. Instrumentation and accessories shall not be connected to humans.

Instructions for use

To avoid injury to an operator the safety precautions given below, and throughout the manual, must be strictly adhered to, whenever the equipment is operated. Only advanced user can use the instrument.

Bio-Logic SAS accepts no responsibility for accidents or damage resulting from any failure to comply with these precautions.

GROUNDING

To minimize the hazard of electrical shock, it is essential that the equipment be connected to a protective ground through the AC supply cable. The continuity of the ground connection should be checked periodically.

ATMOSPHERE

You must never operate the equipment in corrosive atmosphere. Moreover if the equipment is exposed to a highly corrosive atmosphere, the components and the metallic parts can be corroded and can involve malfunction of the instrument.

The user must also be careful that the ventilation grids are not obstructed. An external cleaning can be made with a vacuum cleaner if necessary.

Please consult our specialists to discuss the best location in your lab for the instrument (avoid glove box, hood, chemical products, ...).

AVOID UNSAFE EQUIPMENT

The equipment may be unsafe if any of the following statements apply:

- Equipment shows visible damage,
- Equipment has failed to perform an intended operation,
- Equipment has been stored in unfavourable conditions,
- Equipment has been subjected to physical stress.

In case of doubt as to the serviceability of the equipment, don't use it. Get it properly checked out by a qualified service technician.

LIVE CONDUCTORS

When the equipment is connected to its measurement inputs or supply, the opening of covers or removal of parts could expose live conductors. Only qualified personnel, who should refer to the relevant maintenance documentation, must do adjustments, maintenance or repair

EQUIPMENT MODIFICATION

To avoid introducing safety hazards, never install non-standard parts in the equipment, or make any unauthorised modification. To maintain safety, always return the equipment to Bio-Logic SAS for service and repair.

GUARANTEE

Guarantee and liability claims in the event of injury or material damage are excluded when they are the result of one of the following.

- Improper use of the device,
- Improper installation, operation or maintenance of the device,
- Operating the device when the safety and protective devices are defective and/or inoperable,
- Non-observance of the instructions in the manual with regard to transport, storage, installation,
- Unauthorized structural alterations to the device,
- Unauthorized modifications to the system settings,
- Inadequate monitoring of device components subject to wear,
- Improperly executed and unauthorized repairs,
- Unauthorized opening of the device or its components,
- Catastrophic events due to the effect of foreign bodies.

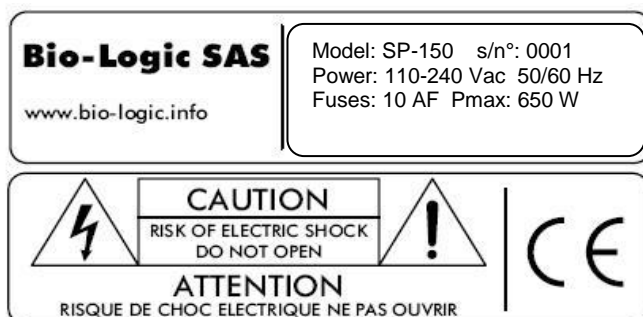
IN CASE OF PROBLEM

Information on your hardware and software configuration is necessary to analyze and finally solve the problem you encounter.

If you have any questions or if any problem occurs that is not mentioned in this document, please contact your local retailer (list available following the link <http://www.bio-logic.info/potentiostat/distributors.html>). The highly qualified staff will be glad to help you.

Please keep information on the following at hand:

- Description of the error (the error message, mpr file, picture of setting or any other useful information) and of the context in which the error occurred. Try to remember all steps you had performed immediately before the error occurred. The more information on the actual situation you can provide, the easier it is to track the problem.
- The serial number of the device located on the rear panel device.



- The software and hardware version you are currently using. On the Help menu, click About. The displayed dialog box shows the version numbers.
- The operating system on the connected computer.
- The connection mode (Ethernet, LAN, USB) between computer and instrument.

General safety considerations



Class I

The instrument is safety ground to the Earth through the protective conductor of the AC power cable.

Use only the power cord supplied with the instrument and designed for the good current rating (10 A max) and be sure to connect it to a power source provided with protective earth contact.

Any interruption of the protective earth (grounding) conductor outside the instrument could result in personal injury.



Guarantee and liability claims in the event of injury or material damage are excluded when they are the result of one of the following.

- Improper use of the device,
 - Improper installation, operation or maintenance of the device,
 - Operating the device when the safety and protective devices are defective and/or inoperable,
 - Non-observance of the instructions in the manual with regard to transport, storage, installation,
 - Unauthorised structural alterations to the device,
 - Unauthorised modifications to the system settings,
 - Inadequate monitoring of device components subject to wear,
 - Improperly executed and unauthorised repairs,
 - Unauthorised opening of the device or its components,
 - Catastrophic events due to the effect of foreign bodies.
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ONLY QUALIFIED PERSONNEL should operate (or service) this equipment.

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1. Introduction

EC-Lab[®] Express software has been designed to control single channel potentiostats (SP-50, SP-150, SP-200, SP-240, SP-300 and HCP803). But it is also compatible with the other potentiostats of our range (VMP2(Z), BiStat, VMP3, VSP and VSP-300). Each channel board of our multichannel instruments is an independent potentiostat/galvanostat that can be controlled by EC-Lab[®] Express software.

The application software package provides useful techniques. They are separated into nine sections: voltamperometric techniques (Cyclic Voltammetry, Chrono-methods,...), impedance techniques, pulsed techniques, stack techniques, corrosion techniques, Ohmic drop techniques, multiplexer techniques and bipotentiostat techniques. Most of these techniques can contain several sequences (for example pulses). Complex experiments are obtained by associations of linked elementary techniques and appear in the experiment frame.

The aim of this manual is to describe every technique available in EC-Lab[®] Express software. This manual is composed up of several chapters. After the introduction, each field will be described. An additional section will detail the way to build complex experiments as linked techniques.

It is assumed that the user is familiar with Microsoft Windows[®] and knows how to use the mouse and keyboard to access the drop-down menus.

WHEN A USER RECEIVES A NEW UNIT FROM THE FACTORY, THE SOFTWARE AND FIRMWARE ARE INSTALLED AND UPGRADED. THE INSTRUMENT IS READY TO BE USED. IT DOES NOT NEED TO BE UPGRADED. WE ADVISE THE USERS TO READ AT LEAST THE FIRST THREE CHAPTERS BEFORE STARTING AN EXPERIMENT.

2. Voltamperometric techniques

EC-Lab[®] Express, together with EC-Lab[®], allows the potentiostat user to control and perform electrochemical experiments on our instruments. For each technique, EC-Lab[®] Express provides a default setting which can be adjusted according to the convenient of the experimenter. The setting parameters related to the running technique can be edited and updated one or more time during the experiment.

This first chapter provides a detailed description of the voltamperometric techniques available with EC-Lab Express. These techniques are listed in the figure below.

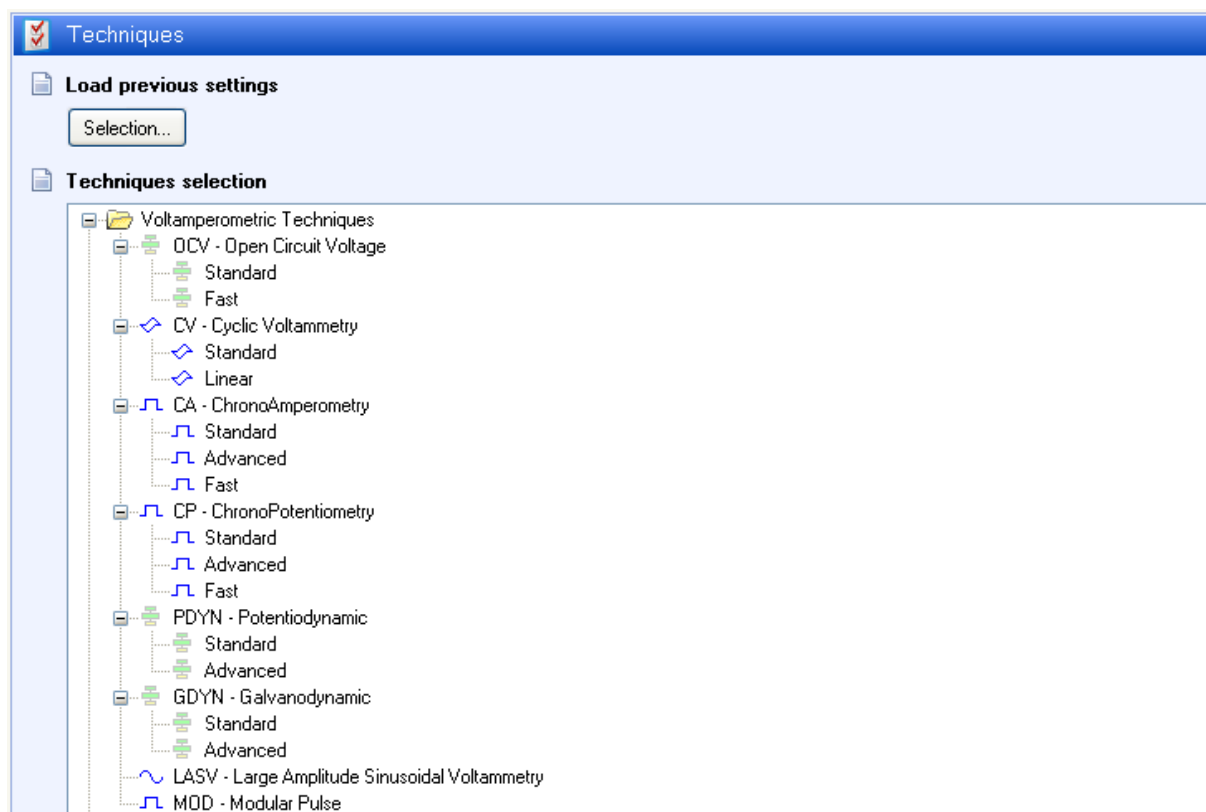


Fig. 1: Overview of the voltamperometric techniques available with EC-Lab Express.

2.1 OCV: Open Circuit Voltage

The Open Circuit Voltage (OCV) consists of a period during which no potential or current is applied to the working electrode. The cell is disconnected from the power amplifier. On the cell, the potential measurement is available, so the evolution of the rest potential can be recorded. This period is commonly used as preconditioning time or for equilibration of the electrochemical cell.

Parameters	Description
Rest for t_R =	1,000 000 sec
Record every dE_R =	100,000 mV
or dt_R =	0,010 00 s
E Range =	+/-2.5 V
Update	

Fig. 2: Open Circuit Voltage technique.

Two kinds of OCP technique are defined : OCV Standard and OCV Fast. The last technique is available only on SP-300 technology.. The difference between the two techniques is the time recording parameter. It is 20 μ s for the standard OCV and 12 μ s for the fast one.

Experiment parameters

Rest for t_R = μ s/ms/.../days

fixes a defined time duration t_R for recording the rest potential.

Record every dE_R = mV

or dt_R = s

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R . . If set to zero, all data points will be stored (every 20 μ s for standard OCV and every 12 μ s for fast OCV).

Data recording with dE_R resolution can reduce the number of experimental points without losing any "interesting" changes in potential. When there is no potential change, only points according to the dt_R value are recorded. If there is a sharp peak in potential, the rate of recording increases.

2.2 CV: Cyclic Voltammetry

2.2.1 CV: Standard Cyclic Voltammetry

Cyclic voltammetry (CV) is the most widely used technique for acquiring qualitative information about electrochemical reactions. CV provides information on redox processes, heterogeneous electron-transfer reactions, and adsorption processes. It offers a rapid location of the redox potential of the electroactive species.

CV consists of scanning linearly the potential of a stationary working electrode using a triangular potential waveform. During the potential sweep, the potentiostat measures the current resulting from electrochemical reactions (consecutive to the applied potential). The cyclic voltammogram is a current response as a function of the applied potential.

The "Cyclic Voltammetry" technique has been detailed a little in EC-Lab[®] Express software manual. This technique corresponds to usual cyclic voltammetry, using a digital potential staircase *i.e.* it runs a defined potential increment in regular time. The software adjusts the potential step to be as small as possible.

The technique is composed of:

- a starting potential E_i ,
- two vertex potentials E_1 and E_2 ,
- a final potential E_f ,
- scan rate definition,
- recording conditions,
- repeat option,
- instrument parameters configuration.

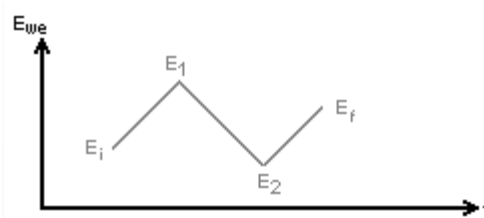


Fig. 3: Cyclic Voltammetry description.

The detailed Parameters window can be seen on the following figure:

Fig. 4: Cyclic Voltammetry detailed setup.

Experiment parameters

Initial potential $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential to a fixed value E (vs. E_{ref} , the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Vertex potential $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

fixes the first potential vertex E_1 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at

the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Vertex potential $E_2 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

fixes the second potential vertex E_2 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Final potential $E_f = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

fixes the final potential E_f . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Scan with $dE/dt = \dots\dots\dots mV/s$

allows the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Record every $dE = \dots\dots\dots mV$

allows the user to record only one point every dE variation. If set to zero, all data points will be stored (every 50 μs for VMP3 technology and 45 μs for the SP-300 technology).

Average

if this box is ticked, an average on the potential is done every dE previously defined.

Measure I from $\dots\dots\dots\%$ of step to $\dots\dots\dots\%$ of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current may be disturbed by the step establishment.

Repeat $n_c = \dots\dots\dots$ times

runs cyclic voltammetry between E_1 and E_2 for n_c times

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.2.2 CV Linear: Linear Cyclic Voltammetry

The CV Linear technique is a cyclic voltammetry technique intended for a fast electrochemical system with a high scan rate. This technique is available in EC-Lab® Express for the SP-300 technology equipped with a Linear Scan Generator module (LSG). This technique allows the user to apply a true analog voltage scan (not discrete scan with steps) between two vertex potentials (E_1 and E_2) to the system with a sampling rate up to 1 μ s. It is possible to couple this technique with hardware ohmic drop compensation.

The screenshot shows the 'Parameters' tab of the software interface. It contains the following settings:

- Initial Potential E_i = 0,000 000 V vs. Eoc
- Vertex Potential E_1 = 1,000 000 V vs. Eref
- Vertex Potential E_2 = -1,000 000 V vs. Eref
- Final Potential E_f = 0,000 000 V vs. Eoc
- Scan with dE/dt = 1,000 V/s
- Record every dE = 1,000 mV (unselected) and dt = 0,001 000 s (selected) FAST
- Repeat n_c = 0 times
- I Range = Auto range
- E Range = +/-2.5 V
- Bandwidth = 8

An 'Update' button is located at the bottom right of the parameter area.

Fig. 5: Cyclic Voltammetry Linear detailed setup.

Experiment parameters

Initial potential E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential in absolute (vs. E_{re}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Vertex potential E_1 = V vs. E_{ref} , E_{oc} , E_{init}

fixes the first potential vertex E_1 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Vertex potential E_2 = V vs. E_{ref} , E_{oc} , E_{init}

sets the second potential vertex E_2 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Final potential $E_f = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init} (disabled)

The Final potential E_f is disabled. Its value is automatically settled at E_i potential ($E_f=E_i$).

Scan with $dE/dt = \dots\dots\dots$ mV/s, mV/min, V/s, KV/s

allows the user to set the scan rate in mV/s The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Record every $dE = \dots\dots\dots$ mV (or $dt = \dots\dots\dots$ s, optional)

allows the possibility to record I with two conditions on potential variation dE or on time variation dt . The two conditions cannot be entered simultaneously. If the dt parameter set to zero all data points will be stored every $15\mu s$.

 Average

if this box is ticked, an average on the potential is done every dE previously defined. For acquisition time lower than $15\mu s$ this box is disabled.

Repeat option for cycling**Repeat $n_c = \dots\dots\dots$ times**

run cyclic voltammetry between E_1 and E_2 for n_c times.

Instruments parameters**I Range = $\dots\dots\dots$**

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Fast acquisition:

When a linear scan generator is plugged in a channel board, the recording parameter dt can be decreased to $1\mu s$. For acquisition time between ($1 \leq dt < 15\mu s$), the average box is disabled and a yellow square displaying "FAST" appears beside the dt parameter (Fig. 6) indicating the fast acquisition configuration. In this case, the automatic current ranging and the data update and the filters are disabled.

Parameters	Description
Initial Potential E_i	= 0,000 000 V Vs. Eoc
Vertex Potential E_1	= 1,000 000 V Vs. Eref
Vertex Potential E_2	= -1,000 000 V Vs. Eref
Final Potential E_f	= 0,000 000 V Vs. Eoc
Scan with dE/dt	= 1,000 V/s
Record every dE	<input type="radio"/> 1,000 mV <input type="checkbox"/> Average
	<input checked="" type="radio"/> dt = 0,000 001 s FAST
Repeat n_c	= 0 times
I Range	= 10 nA
E Range	= +/-2.5 V
Bandwidth	= 8
Update	

Fig. 6: Fast Cyclic Voltammetry setup.

2.3 CA: Chronoamperometry

2.3.1 CA Standard

The basis of the controlled-potential technique is the measurement of the current response to an applied potential step.

Chronoamperometry involves stepping the potential of the working electrode from an initial potential, at which, generally, no faradic reaction occurs, to a potential E_i at which no electroactive species exist (at the beginning of the experiment). The current-time response reflects the change in the concentration gradient in the vicinity of the surface. Chronoamperometry is often used for measuring the diffusion coefficient of electroactive species or the surface area of the working electrode. This technique can also be applied to the study of electrode processes mechanisms.

An alternative and very useful mode for recording the electrochemical response is to integrate the current, so that one obtains the charge passed as a function of time. This is the chronocoulometric mode that is particularly used for measuring the quantity of adsorbed reactants.

The potential steps can be set to a fixed value (E_i), a value relative to the last rest potential (E_{oc}) or a value relative to the last controlled potential (E_{pc}).

The detailed flow diagram is made as follows:

- potential step,
- potential sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

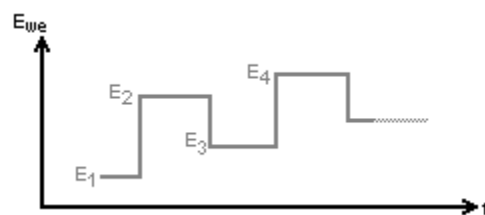


Fig. 7: Chronoamperometry description.

The detailed parameter setup is displayed on the following picture:

Fig. 8: Chronoamperometry detailed setup.

Experiment parameters

Apply $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique

for $t_1 = \dots\dots\dots$ μ s/ ms / \dots / $days$

fixes the potential step duration.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (potential steps) to the experiment.

Record I every $dl = \dots$ pA/ \dots / A , or $dt = \dots$ s

if two recording conditions are entered simultaneously, the first reached determines the recording condition. A zero value results in the storage of every data point (every 24 μ s for VMP3 technology and every 21 μ s for SP-300 technology).

runs potential steps sequences for n_c times

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.3.2 CA Adv: Advanced Chronoamperometry

The Advanced Chronoamperometry (CA Adv) is an advanced version of the standard CA technique (report to the CA description for more details about the technique). This technique is based on the same principle as the CA technique except that it is possible to add three additional limits.

Fig. 9: Chronoamperometry Advanced detailed setup.

Experiment parameters

Apply $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

for $t_1 = \dots \mu\text{s}/\text{ms}/\dots/\text{days}$

fixes the potential step duration.

Limits: $I/\text{IN1}/\text{IN2}/Q </> \dots A/C \text{ OR/AND}$

defines a limit on current or on IN1 or on IN2 or on charge Q and the sign of this limit. AND function allows adding different limits, each of them should be reached to go to next step. OR function allows selecting one limit among the other and to go to the next step when reached.

If True Next Sequence/ Next Technique/ Stop Experiment

defines the action to do when limit(s) is (are) reached.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (potential steps) to the experiment.

Record I every $dt = \dots \text{pA}/\dots/\text{A}$, or $dt = \dots \text{s}$

if two recording conditions are entered simultaneously, the first reached determines the recording. A zero value results in the storage of every data point (every 40 μs for VMP3 technology and every 34 μs for SP-300 technology).

Repeat $n_c = \dots \text{times}$

runs potential steps sequences for n_c times

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.3.3 CA Fast: Fast Chronoamperometry

The Fast Chronoamperometry (CA Fast) is a CA technique intended for a fast electrochemical system with a high scan rate. This technique allows the use of an analog Scan with a recording time of 12 μs . This technique is available with the SP-300 technology.

The screenshot shows a software window titled 'Parameters' with a 'Description' tab. The main area contains several input fields and dropdown menus. At the top, there's a section for 'Apply $E_1 = 1,000\ 000$ V vs. E_{ref} ' and 'for $t_1 = 0,500\ 000$ sec'. Below this, there are buttons for adding (+) and removing (-) sequences, and a dropdown menu showing '1'. Further down, there are fields for 'Record every $dl = 0,100$ A' or 'or $dt = 0,010\ 00$ s', and 'Repeat $n_c = 0$ times'. At the bottom, there are three radio buttons for 'I Range = Auto range', 'E Range = +/-2.5V', and 'Bandwidth = 8'. An 'Update' button is located at the bottom right.

Fig. 10: Fast Chronoamperometry detailed setup.

Experiment parameters

Apply $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

For $t_1 = \dots\dots\dots$ μ s/ms/.../days

fixes the potential step duration.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (potential steps) to the experiment.

Record I every $dl = \dots$ pA/.../A, or $dt = \dots$ s

if two recording conditions are entered simultaneously, the first reached determines the recording. A zero value results in the storage of every data point (every 14 μ s).

Repeat $n_c = \dots\dots\dots$ times

runs potential steps sequences for n_c times

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.4 CP: Chronopotentiometry

2.4.1 CP Standard

The Chronopotentiometry is an electrochemical technique in which the current is controlled and the potential is the variable determined as a function of time. The chronopotentiometry protocol is similar to the Chronoamperometry / Chronocoulometry protocol, with potential steps being replaced by current steps. The constant current is applied between the working and the counter electrode.

This technique can be used for different kinds of analysis or to investigate electrode kinetics, but, it is considered less sensitive than voltammetric techniques for analytical uses. Generally, $E_{we} = f(t)$ contains plateaus that correspond to the redox potential of electroactive species.

The detailed flow diagram is made as follows:

- current step,
- current sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

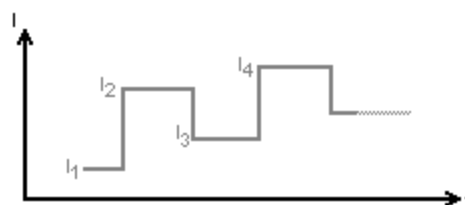


Fig. 11: Chronopotentiometry description.

The detailed parameter setup is displayed on the following picture:
Note that this technique uses sequences.

Fig. 12: Chronopotentiometry detailed parameters.

Experiment parameters

Apply $I_1 = \dots\dots\dots$ pA/nA/.../A vs. I_{init} , None

the applied current is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

for $t_1 = \dots\dots\dots$ μ s/ms/.../days

fixes the current step duration.

Add sequences

the “+” and “-“ buttons enable the user to add or remove sequences (current steps) to the experiment.

Record I every $dE = \dots$ mV, or $dt = \dots$ s

two recording conditions can be entered simultaneously. Then the first condition reached determines the recording. A zero value results in the storage of every data point (every 24 μ s for VMP3 technology and 21 μ s for the SP-300 technology).

Repeat $n_c = \dots\dots\dots$ times

runs current sequences for n_c times.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.4.2 CP Adv: Advanced Chronopotentiometry

The Advanced Chronopotentiometry (CP Adv) is an advanced version of the standard CP technique (report to the CP description for more details about the technique). This technique is based on the same principle that the CP technique except that it is possible to add three additional limits

Fig. 13: Advanced Chronopotentiometry detailed parameters.

Experiment parameters

Apply $I_1 = \dots\dots\dots$ pA/nA/.../A vs. I_{init} , None

the applied current is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

for $t_1 = \dots\dots\dots$ μ s/ms/.../days

fixes the current step duration.

Limits: E/IN1/IN2/Q </> A OR/AND

defines a limit on potential or on IN1 or on IN2 or on charge Q and the sign of this limit. AND function allows adding different limits, each of them should be reached to go to next step. OR function allows selecting one limit among the other and to go to the next step when reached.

If True Next Sequence/ Next Technique/ Stop Experiment

defines the action to do when the first limit is reached.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (current steps) to the experiment.

Record I every $dE = \dots$ mV, or $dt = \dots$ s

two recording conditions can be entered simultaneously. Then the first condition reached determines the recording. A zero value results in the storage of every data point (every 40 μ s for VMP3 technology and 34 μ s for the SP-300 technology).

Repeat $n_c = \dots$ times

runs current sequences for n_c times.

Instruments parameters**I Range =**

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.4.3 CP Fast: Fast Chronopotentiometry

The Chronopotentiometry is a fast version of the Chronopotentiometry technique in which the smallest recording time is 14 μ s. (report to the CP description for more details about the technique). This technique is available with SP200/240, SP300 and VSP300 potentiostats

The screenshot shows a software interface for configuring Fast Chronopotentiometry. It includes fields for applying a current I_1 (0,500 mA) for a duration t_1 (0,500 000 sec). Recording parameters are set to $dE = 100,000$ mV or $dt = 0,010 00$ s, with $n_c = 0$ repeats. Instrument settings include an I Range of 1 mA, an E Range of +/-2.5 V, and a Bandwidth of 8. An 'Update' button is present at the bottom right.

Fig. 14: Fast Chronopotentiometry detailed parameters.

Experiment parameters**Apply $I_1 = \dots$ pA/nA/.../A vs. I_{init} , None**

the applied current is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

for $t_1 = \dots \mu\text{s}/\text{ms}/\dots/\text{days}$

fixes the current step duration.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (current steps) to the experiment.

Record I every $dE = \dots \text{mV}$, or $dt = \dots \text{s}$

two recording conditions can be entered simultaneously. Then the first condition reached determines the recording. A zero value results in the storage of every data point (every 14 μs).

Repeat $n_c = \dots$ times

runs current sequences for n_c times.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.5 PDyn: Potentiodynamic

2.5.1 Standard Potendynamic: PDyn

The potentiodynamic technique allows the user to perform combinations of potentiodynamic periods with different scan rates and different potential vertices. The detailed flow diagram is made as follows:

- potential scan to E_1 ,
- potential sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

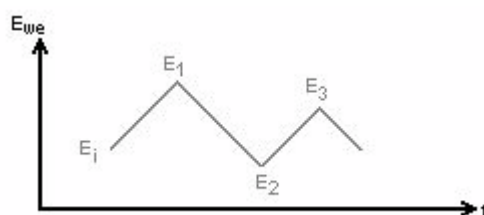


Fig. 15: Potentiodynamic description

The detailed parameter setup is displayed on the following picture:
Note that this technique uses sequences too.

Parameters | Description

Initial
Potential E_i = 0,000 000 V Vs. E_{ref}

Scan with dE/dt = 100,000 mV/s
Potential E_1 = 1,000 000 V Vs. E_{ref}

+ - 1

Record every dE = 10,000 mV
Measure I from 50 % of step
to 100 % of step
Repeat n_c = 0 times

I Range = Auto range
E Range = +/-2.5 V
Bandwidth = 8

Update

Fig. 16: Potentiodynamic detailed parameters.

Experiment parameters

Initial Potential E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Scan with dE/dt = mV/s

sets the current scan rate.

Potential E_1 = V vs. E_{ref} , E_{oc} , E_{init}

fixes the potential vertex. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (potential scans) to the experiment with different vertex potential.

Record every dE = mV

allows the user to record only one point every dE variation. If set to zero, all data points will be stored (every 50 μ s).

Measure I from % of step to % of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current I may be disturbed by the step establishment.

Repeat $n_c = \dots\dots\dots$ times

runs potential scan sequences for n_c times.

Instruments parameters**I Range =**

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.5.2 Potendynamic Advanced: PDyn Adv

The advanced potentiodynamic technique is an advanced version of the standard potentiodynamic technique (report to the potentiodynamic technique description for more details about the technique)

This technique is based on the same principle that the PDyn technique except that it is possible to add three additional limits. Please refer to PDYN technique for more details.

The screenshot shows a software interface with a 'Parameters' tab. The parameters are as follows:

- Initial Potential $E_i = 0,000\,000$ V Vs. Eref
- Scan with $dE/dt = 100,000$ mV/s
- Potential $E_0 = 1,000\,000$ V Vs. Eref
- Limits:
 - I < 0,000 A OR
 - I < 0,000 A OR
 - I < 0,000 A
- If True: Next Sequence
- Record every $dE = 10,000$ mV
- Measure I from 50 % of step to 100 % of step
- Repeat $n_c = 0$ times
- I Range = Auto range
- E Range = +/-2.5 V
- Bandwidth = 8

An 'Update' button is located at the bottom right of the parameter area.

Fig. 17: Advanced potentiodynamic detailed parameters.

Experiment parameters

Initial Potential $E_i = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Scan with $dE/dt = \dots\dots\dots mV/s$

sets the current scan rate.

Potential $E_1 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

fixes the potential vertex E_1 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Limits: $I/IN1/IN2/Q </> \dots\dots\dots A/C$ OR/AND

defines a limit on current or on IN1 or on IN2 or on charge Q and the sign of this limit. AND function allows adding different limits, each of them should be reached to go to next step. OR function allows selecting one limit among the other and to go to the next step when reached.

If True Next Sequence/ Next Technique/ Stop Experiment

defines the action to do when the limit is reached.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (potential scans) to the experiment with different vertex potential.

Record every $dE = \dots\dots\dots mV$

allows the user to record only one point every dE variation. If set to zero, all data points will be stored (every 60 μs).

Measure I from $\dots\dots\dots \%$ of step to $\dots\dots\dots \%$ of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current I may be disturbed by the step establishment.

Repeat $n_c = \dots\dots\dots$ times

runs potential scan sequences for n_c times.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.6 GDyn: Galvanodynamic

2.6.1 Standard Galvanodynamic: GDyn

The Galvanodynamic technique allows the user to perform combinations of galvanodynamic periods with different scan rates and different current vertex. The detailed flow diagram is made as follows:

- current scan to I_1 ,
- current sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

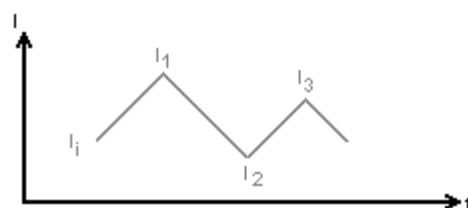


Fig. 18: Galvanodynamic description.

The detailed parameter setup is displayed on the following picture:

Fig. 19: Galvanodynamic detailed parameters.

Experiment parameters

Initial Current $I_i = \dots\dots\dots \text{pA/nA}/\dots/\text{A}$ vs. I_{init} , None

fixes the starting current I_i . It is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

Scan with $dl/dt = \dots\dots\dots \text{A/s}, \text{mA/s}, \mu\text{A/s}, \text{nA/s}, \text{pA/s}$

sets the current scan rate.

Current $I_1 = \dots\dots \text{pA/nA/.../A}$ vs. I_{init} , None

fixes the current vertex I_1 . It is defined in absolute (None) or according to the initial current measured at the beginning of the technique (I_{init}). It can be 0 if no technique was previously applied, or it can be the last current value measured in the previous technique.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (current scans) to the experiment with different vertex current.

Record every $dI = \dots\dots \text{pA/nA/.../A}$

allows the user to record only one point every dI variation. If set to zero, all data points will be stored (every 50 μs).

Measure E from $\dots\dots$ % of step to $\dots\dots$ % of step

selects the part of each current step (from 1 to 100%) where the potential is measured and the average calculation will be done, to exclude the first points where the potential may be disturbed by the step establishment.

Repeat $n_c = \dots\dots$ times

runs current scan sequences for n_c times.

Instruments parameters**I Range = $\dots\dots$**

enables the user to select the current range.

E Range = $\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.6.2 Galvanodynamic Advanced: GDyn Adv

The advanced Galvanodynamic technique is an advanced version of the standard Galvanodynamic technique (report to the Galvanodynamic technique description for more details about the technique). This technique is based on the same principle that the Galvanodynamic technique except that it is possible to add three additional limits

Fig. 20: Advanced Galvanodynamic setup.

Experiment parameters

Initial Current $I_i = \dots\dots\dots \text{pA/nA/.../A}$ vs. I_{init} , None

fixes the initial current I_i . It is defined in absolute or according to the initial current measured at the beginning of the technique. It can be zero if no technique was previously applied, or it can be the last current value measured in the previous technique.

Scan with $dl/dt = \dots\dots\dots \text{A/s, mA/s, } \mu\text{A/s, nA/s, pA/s}$

sets the current scan rate.

Current $I_1 = \dots\dots\dots \text{pA/nA/.../A}$ vs. I_{init} , None

fixes the current vertex I_1 . It is defined in absolute or according to the initial current measured at the beginning of the technique. It can be 0 if no technique was previously applied, or it can be the last current value measured in the previous technique.

Limits: E/IN1/IN2/Q </> A/C OR/AND

defines a limit on potential or on IN1 or on IN2 or on charge Q and the sign of this limit. AND function allows adding different limits, each of them should be reached to go to next step. OR function allows selecting one limit among the other and to go to the next step when reached.

If True Next Sequence/ Next Technique/ Stop Experiment

defines the action to do when the first limit is reached.

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (current scans) to the experiment with different vertex current.

Record every $dI = \dots\dots pA/nA.../A$

allows the user to record only one point every dI variation. If set to zero, all data points will be stored (every 60 μs).

Measure E from % of step to % of step

selects the part of each current step (from 1 to 100%) where the potential is measured and the average calculation will be done, to exclude the first points where the potential may be disturbed by the step establishment.

Repeat $n_c = \dots\dots$ times

runs current scan sequences for n_c times.

Instruments parameters**I Range =**

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.7 LASV: Large Amplitude Sinusoidal Voltammetry

Large Amplitude Sinusoidal Voltammetry (LASV) is an electrochemical technique where the potential excitation of the working electrode is a large amplitude sinusoidal waveform. Similar to the cyclic voltammetry (CV) technique, it gives qualitative and quantitative information on the redox processes. In contrast to the CV, the double layer capacitive current is not subject to sharp transitions at reverse potentials. As the electrochemical systems are non-linear the current response exhibits high order harmonics at large sinusoidal amplitudes. Valuable information can be found from data analysis in the frequency domain.

The technique is composed of:

- a starting potential,
- a frequency definition f_s ,
- a potential range definition from E_1 to E_2 ,
- the possibility to repeat n_p times potential scan.

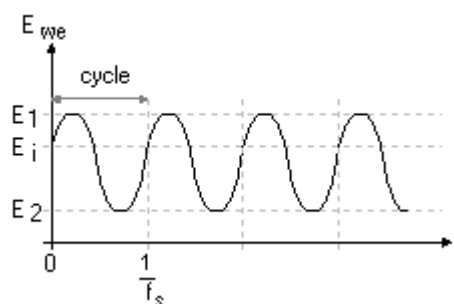


Fig. 21: LASV description.

The detailed Parameters window can be seen on the following figure:

Fig. 22: LASV detailed parameters.

Experiment parameters

Initial potential $E_i = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

$f_s = \dots\dots MHz/kHz/Hz/mHz/\mu Hz$

allows the user to set the value of frequency which will define the scan rate.

$E_1 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

fixes the first potential vertex E_1 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

$E_2 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets E_2 vertex potential. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Repeat $n_p = \dots\dots\dots$ times

runs LASV technique between E_1 and E_2 for n_p times

Record every $dI = \dots\dots pA/nA/.../A$ and $dt = \dots\dots s$

offers the possibility to record I with two conditions on the current variation dI and (or) on time variation. If set to zero, all data points will be stored (every 50 μs).

Instruments parameters

Repeat $n_c = \dots\dots\dots$ times

repeats all the sequences n_c times.

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: for this technique, recording conditions could be defined independently for each sequence.

2.8 MOD: Modular Pulse

The Modular pulse technique (MOD) allows the user to control successively in different sequences the current or the voltage of the cell. This technique can include galvanostatic and potentiostatic sequences. The switch from one sequence to the other is very fast. The recording conditions included in the sequence (rc) offer the possibility to record only few

sequences in a long time experiment. This technique is particularly useful for electrochemical coating.

Two kind of sequence can be used in the same experiment: potentiostatic sequence and galvanostatic sequence.

2.8.1 Potentiostatic Mode

The screenshot shows a software interface for setting up a potentiostatic experiment. The 'Parameters' tab is selected. The 'Mode' is set to 'Potentiostatic'. The 'Apply E' field is set to 1,000,000 V vs. 'Eref'. The 'for t' field is set to 0,500,000 sec. The 'Record every dt' field is set to 0,010,000 s. There is a checkbox for 'or dl' with a value of 0,000 A. Below, the 'Repeat n_c' field is set to 0 cycles and the 'Record every r_c' field is set to 1 cycle. At the bottom, the 'I Range' is set to 10 mA, the 'E Range' is set to +/-2.5 V, and the 'Bandwidth' is set to 8. An 'Update' button is located at the bottom right.

Fig. 23: Potentiostatic mode of the Modular pulse setup.

Experiment parameters

Apply E = V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

for t = μ s/ms/.../days

fixes the potential step duration.

Record I every dt = s or dl = pA.../A

if two recording conditions are entered simultaneously, the first reached determines the recording. A zero value results in the storage of every data point (every 100 μ s).

Add sequences

the "+" and "-" buttons enable the user to add or remove sequences (potential steps) to the experiment.

Repeat n_c = cycles

runs potential steps sequences for n_c cycles

Record I every r_c =cycles

The recording parameter r_c allows the user to record only few sequences in a long time experiment. During an experiment with n_c cycles, the r_c satisfy $1 \leq r_c \leq n_c + 1$

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

2.8.2 Galvanostatic Mode

The screenshot shows a software interface for setting up a galvanostatic experiment. The 'Parameters' tab is active. The 'Mode' is set to 'Galvanostatic'. The 'Apply I' is set to 0,500 mA, 'for t' is 0,500 000 sec, and 'Record every dt' is 0,010 00 s. There is an option for 'or dE = 0,000 mV'. Below this, there are fields for 'Repeat n_c = 0 cycles' and 'Record every r_c = 1 cycles'. At the bottom, there are dropdown menus for 'I Range = 10 mA', 'E Range = +/-2.5 V', and 'Bandwidth = 8'. An 'Update' button is located at the bottom right.

Fig. 24: Galvanostatic Modular pulse setup.

Experiment parameters

Apply I = pA/nA/.../A vs. I_{init} None

the applied current is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

for t = μ s/ms/.../days

fixes the current step duration.

Record I every dt = s or dE = mV

two recording conditions can be entered simultaneously. Then the first condition reached determines the recording. A zero value results in the storage of every data point (every 100 μ s).

Add sequences

the “+” and “-“ buttons enable the user to add or remove sequences (current steps) to the experiment.

Repeat $n_c = \dots\dots\dots$ cycles

runs current sequences for n_c cycles.

Record I every $r_c = \dots\dots\dots$ cycles

The recording parameter r_c allows the user to record only few sequences in a long time experiment. During an experiment with n_c cycles, the r_c satisfy $1 \leq r_c \leq n_c + 1$

Instruments parameters**I Range =**

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

3. Electrochemical Impedance Spectroscopy

Among the modern computational techniques, the Electrochemical Impedance Spectroscopy (EIS) is now a powerful tool for examining many chemical and physical processes in solution as well as in solids. EIS finds many applications in corrosion, battery, fuel cell development, sensors and physical electrochemistry and can provide information on reaction parameters, corrosion rates, electrode surfaces porosity, coating, mass transport, and interfacial capacitance measurements.

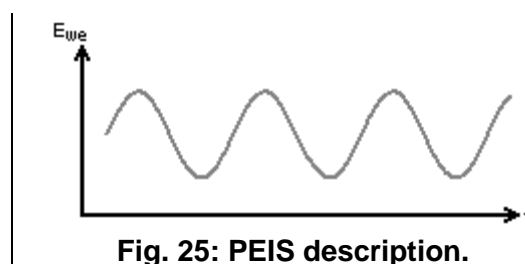
Our instruments equipped with EIS capability can perform impedance measurements from 10 μHz to 1 MHz pour les potentiostat SP-150, VSP, VMP3 (200 kHz for channel boards delivered before July 2005) and from 10 μHz to up to 7 MHz for SP-300 technology. With boosters, this high limit is reduced.

The SP-50 is not concerned with this section, as this instrument is not EIS capable.

3.1 PEIS: Potentio Electrochemical Impedance Spectroscopy

The PEIS experiment performs impedance measurements in potentiostatic mode by applying a sinus around a potential E that can be set to a fixed value or relatively to the cell's equilibrium potential:

- fixe a DC potential,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.



The potential of the working electrode follows the equation:

$$E = E_{we} + V_a \sin(2\pi ft)$$

The detailed parameter setup is made of:

Parameters	Description
Set E_{we} =	0,000 000 V vs. Eref
Wait for t_s =	1,000 000 sec
Record every dl =	1,000 mA
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude V_a =	10,0 mV
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	<input checked="" type="radio"/> Auto range
Bandwidth =	<input checked="" type="radio"/> 8
Update	

Fig. 26: PEIS detailed parameters.

Initial DC potential

Set E_{we} = V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Wait for t_s = μ s/ms/.../days

applies E_{we} for a t_s duration. Set t_s large enough to wait for the cell current stabilization, if the applied potential is different to the open circuit potential. During this period, no impedance measurement is done.

Record every dl = pA/nA/.../A or dt = s

offers the ability to record E_{we} and I during the DC period before the AC simulation with two conditions on the current variation dl and (or) on time variation.

AC measurement

Scan from f_i = MHz/kHz/Hz/mHz/ μ Hz to f_f = MHz/kHz/Hz/mHz/ μ Hz

defines the initial (f_i) and the final (f_f) frequencies of the scan. To have the first measured point more quickly, it is recommended to scan from the highest frequencies to the lowest ones, but it is possible to reverse the frequencies scan order.

With N_T = points

defines the total number of frequency points N_T between the scan bounds f_i and f_f .

Point spacing: Logarithmic or linear

defines the point spacing.

For example, a scan from $f_i = 100$ kHz to $f_f = 1$ kHz with $N_t = 11$ total number of points in linear spacing, will make measurements at these frequencies (Hz):

100, 90, 80, 70, 60, 50, 40, 30, 20, 10, 1.

Sinus amplitude $V_a = \dots\dots$ mV

sets the AC sinus amplitude to V_a . It is added to the DC potential level.

Wait for $p_w = \dots\dots$ period before each frequency

offers the ability to add a delay before the measurement at each frequency. This delay is defined as a part of the period. Of course for low frequencies the delay may be long.

Average $N_a = \dots\dots\dots$ mesure(s)

repeats N_a measure(s) and average values for each frequency.

Drift correction

function resulting in the correction of the DC level drift. This feature is especially dedicated to low frequencies.

Note that if this option is selected, the sinus frequencies are evaluated over 2 periods (instead of 1), increasing the acquisition time by a factor of 2.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

3.2 GEIS: Galvano Electrochemical Impedance Spectroscopy

This technique is very close to the Potentiostatic Impedance protocol (PEIS), except that the current is controlled instead of the potential. So report to the PEIS experiment section for more details.

- fixes a DC current,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.

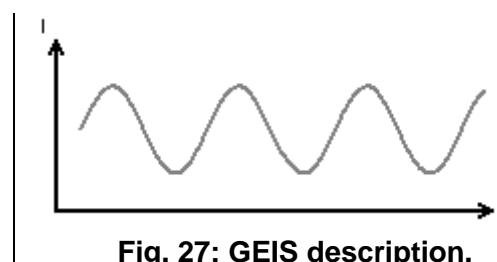


Fig. 27: GEIS description.

Parameters	Description
Set I_s =	0,000 mA Vs. None
Wait for t_s =	1,000 000 sec
Record every dE =	100,000 mV
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude I_a =	1,000 mA
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	<input checked="" type="radio"/> 10 mA
Bandwidth =	<input checked="" type="radio"/> 8
Update	

Fig. 28: GEIS detailed parameters.

Note that the applied current can be defined in absolute (None) or according the initial measured current (I_{init}).

Instead of I_a , one can consider the current peak to peak amplitude (I_{pp}) related to I_a with $I_{pp} = 2I_a$ or the Root Mean Square (RMS) voltage related to I_a with $I_{RMS} = I_a/\sqrt{2}$. The detailed GEIS set up is similar to that of PEIS set up.

3.2.1 Visualisation of impedance data files

Standard visualisation modes

The EC-Lab[®] Express software provides a full range of variables and visualisation modes defined by default. When an impedance data file is displayed, click on “Selector” to show all the variables and the visualisation modes available with impedance data files:

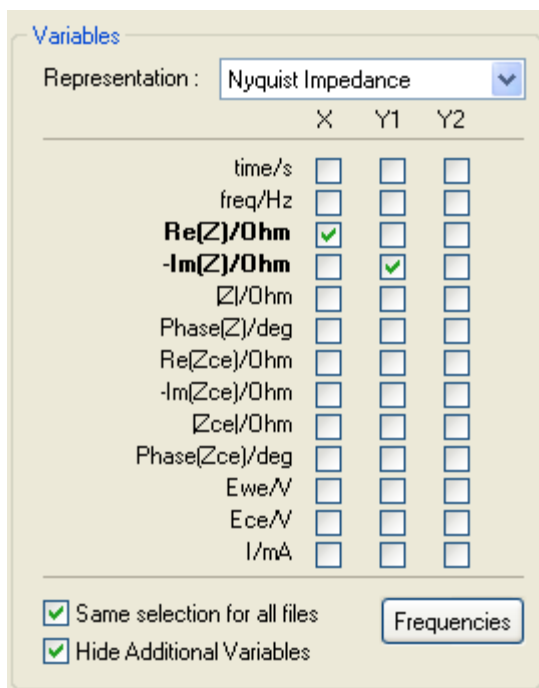


Fig. 29: EIS plot selector.

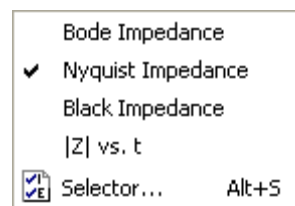


Fig. 30: EIS graph selection.

Bode, Nyquist and Black diagrams can be plotted according to EC-Lab[®] Express software's predefined graph visualisation modes.

3.2.2 Frequency vs. time plot

It is possible to perform impedance measurements at different time intervals, to follow the evolution of $|Z|$ (or $\text{Im}(z)$, $\text{Re}(z)$, $\text{phase}(z)$) versus time for each frequency value.

The user can repeat a PEIS impedance experiment where the potential E is fixed for a given time t_E (for example 30 min).

After a run, open the impedance file in a graphic window, and click on **Selector**. The "file selection" window appears (figure below). Then select **time/s** for X-axis and choose the parameter you want to plot on Y1-axis ($|Z|$ in our example).

Note: for a Z vs. time plot, the time variable must be plotted on the X-axis.

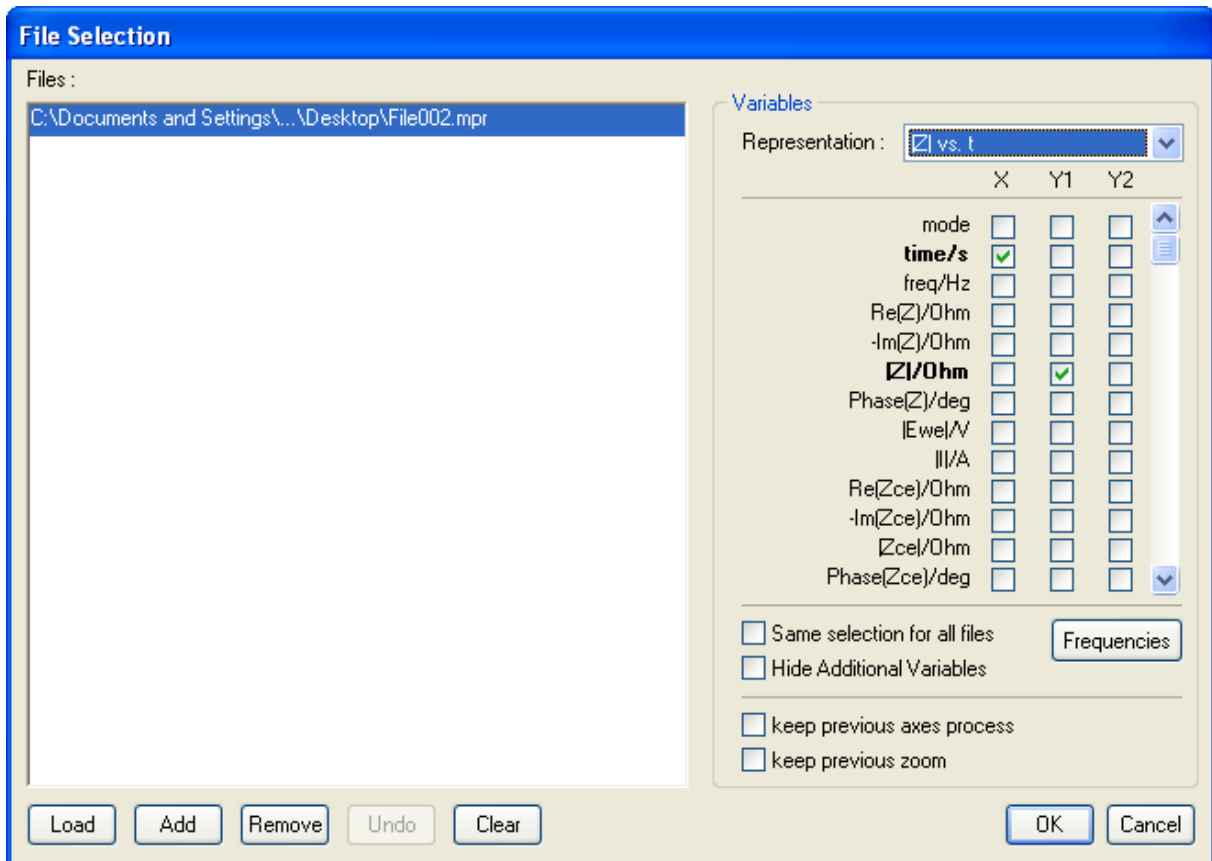


Fig. 31: File selection display.

Select Z(t) plot in the combo box. Then the following window is displayed for selecting the frequencies you want to plot.

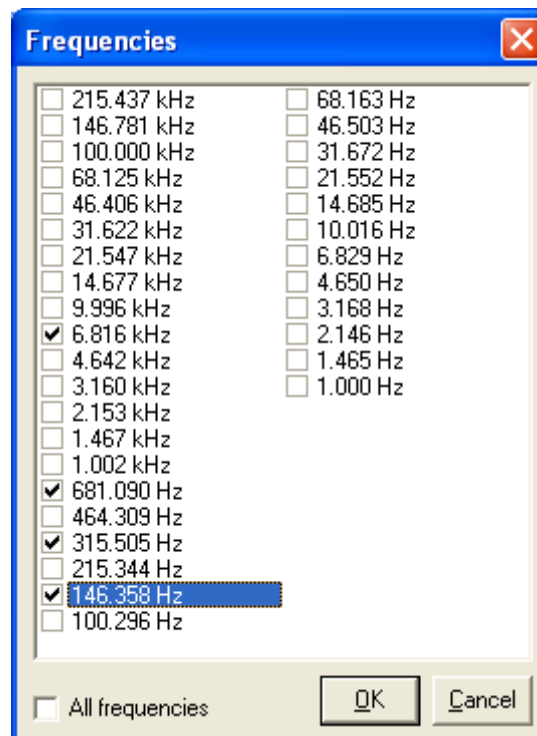


Fig. 32: Z vs. time display used to select frequencies.

Choose the desired frequencies and click **Ok**. The graphic representation will automatically display one trace for each chosen frequency. In the graphic display, $|Z| = f(t)$ is represented by the four different frequencies selected before.

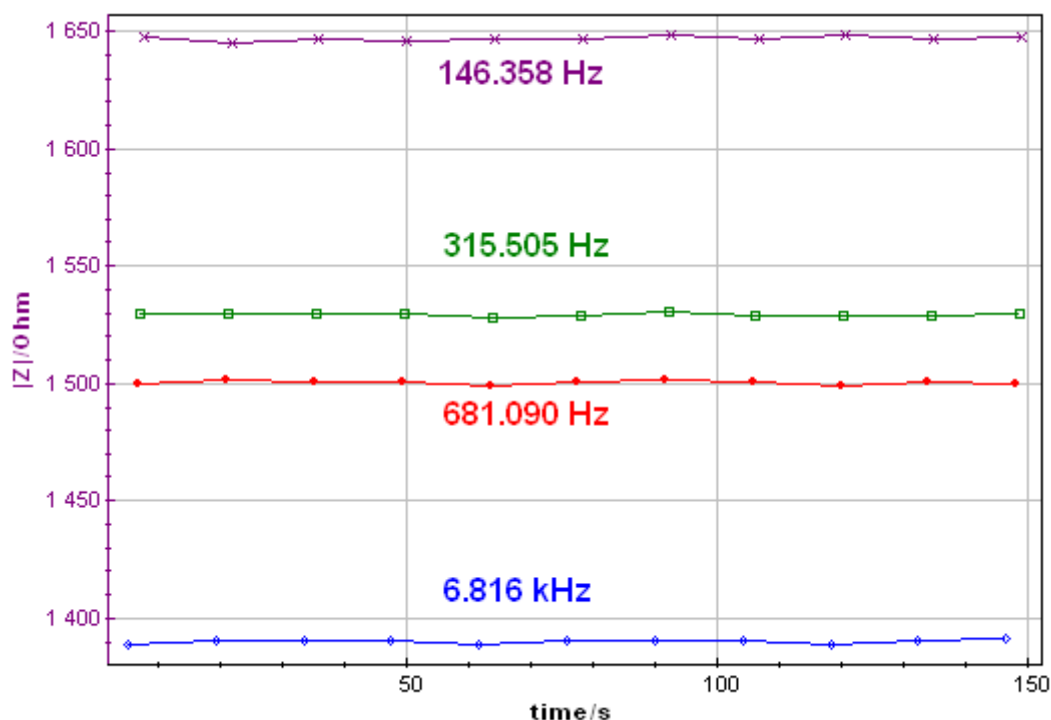


Fig. 33: Graphic display for 4 different frequencies.

3.3 SPEIS: Staircase Potenti Electrochemical Impedance Spectroscopy

The SPEIS and SGEIS techniques are designed to perform successive impedance measurements (on a whole frequency range) during a potential sweep (SPEIS) or a current sweep (SGEIS). The main application of these techniques is to study electrochemical reaction kinetics along voltamperometric ($I(E)$) curves in analytical electrochemistry. Thus these techniques find all their interest in studying the complexity of non-stationary interfaces with faradic processes where the total AC response (whole frequency range) is required. Another common application of such techniques is semi-conductor materials study. For these stationary systems only two or three frequencies for each potential step are required to determine the donor density and the flat band potential

SPEIS : Description

The SPEIS technique consists of a staircase potential sweep (potential limits and number of steps defined by the user). An impedance measurement (with an adjustable number of frequencies) is performed on each potential step. For all these applications a Mott-Schottky plot ($1/C^2$ vs. E_{we}) can be displayed and a special linear fit is applied to extract the semi-conductor parameters.

- potential scan definition with potential limits and number of potential steps,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.

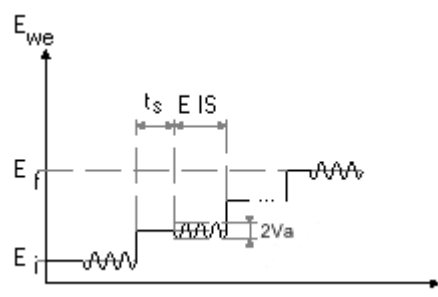


Fig. 34: SPEIS description.

Parameters	Description
Scan from E_i =	0,000 000 V Vs. Eref
to E_f =	1,000 000 V Vs. Eref
with N =	10 potential steps
Wait for t_s =	1,000 000 sec
Record every dl =	1,000 mA
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude V_a =	10,0 mV
wait for p_w =	0,10 period(s) before each frequency measure(s)
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	Auto range
Bandwidth =	8
Update	

Fig. 35: SPEIS detailed parameters.

DC potential scan

Scan from $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init} to $E_f = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the initial and the final potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

With $N = \dots\dots\dots$ potential steps

defines the number of potential steps between E_i and E_f .

Wait for $t_s = \dots\dots\dots$ μ s/ms/.../days

applies E_{we} for a t_s duration. Set t_s large enough to wait for the stabilization. During this period, no impedance measurement is done.

□ **Record every $dl = \dots \text{ pA/nA}/\dots/\text{A}$ or $dt = \dots \text{ s}$**

offers the ability to record E_{we} and I during the DC period before the AC simulation with two conditions on the current variation dl and (or) on time variation.

AC measurement

Scan from $f_i = \dots \text{ MHz/kHz/Hz/mHz/}\mu\text{Hz}$ to $f_f = \dots \text{ MHz/kHz/Hz/mHz/}\mu\text{Hz}$

defines the initial (f_i) and final (f_f) frequencies of the scan. To have the first measured point more quickly, it is recommended to scan from the highest frequencies to the lowest ones, but it is possible to reverse the frequencies scan order.

With $N_T = \dots \text{ points}$

defines the total number of frequency points N_T between the scan bounds f_i and f_f .

Point spacing: Logarithmic or linear

defines the point spacing.

For example, a scan from $f_i = 100 \text{ kHz}$ to $f_f = 1 \text{ kHz}$ with $N_T = 11$ total number of points in linear spacing, will make measurements at these frequencies (Hz):

100, 90, 80, 70, 60, 50, 40, 30, 20, 10, 1.

Sinus amplitude $I_a = \dots \text{ pA/nA}/\dots/\text{A}$

sets the AC sinus amplitude to E_a . It is added to the DC potential level.

Wait for $p_w = \dots \text{ period before each frequency}$

offers the ability to add a delay before the measurement at each frequency. This delay is defined as a part of the period. Of course for low frequencies the delay may be long.

Average $N_a = \dots \text{ measure(s)}$

repeats N_a measure(s) and average values for each frequency.

Drift correction

function resulting in the correction of the DC level drift. This feature is more especially dedicated to low frequencies.

Note that if this option is selected, the sinus frequencies are evaluated over 2 periods (instead of 1), increasing the acquisition time by a factor of 2.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Graph tool: Mott-Schottky plot

For the SPEIS technique particularly used in semi-conductor materials study (Mott-Schottky experiments), it is possible to display the " $1/C^2$ vs. E_{we} " or " $1/C$ vs. E_{we} " plot when selecting "**Mott-Schottky**" in the rapid selection combo box. This graphic display is available during the run because the capacitance values are automatically calculated during the experiment. When the Mott-Schottky plot is selected, the user must choose several frequencies among all the recorded frequencies. Moreover, a special fit "**Mott-Schottky fit**" has been built to determine the semi-conductor parameters (flatband potential, donor density). For more details about this plot, refer to the EC-Lab[®] Express software manual.

Note:

- Note that potential amplitude (V_a) is related to V_{pp} by $V_a = V_{pp}/2$ or to the Root Mean Square (RMS) voltage related to V_{pp} by $V_{RMS} = V_{pp}/(2\sqrt{2})$,
- it is possible to modify on-line the settings of an impedance measurement during the experiment. To accept the change the user has to click on the Update button

Update

3.4 SGEIS: Staircase Galvano Electrochemical Impedance Spectroscopy

With the SGEIS technique, the potentiostat works as a galvanostat and applies a current sweep (staircase shape). An impedance measurement (whole frequency range) can be performed on each current step. The user can also select several frequencies.

The SGEIS experiment performs impedance measurements in galvano mode by applying a sinus around a current I . The impedance measurement is repeated on each current step

The detailed flow diagram is made of:

- current scan definition with current limits and number of current steps,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.

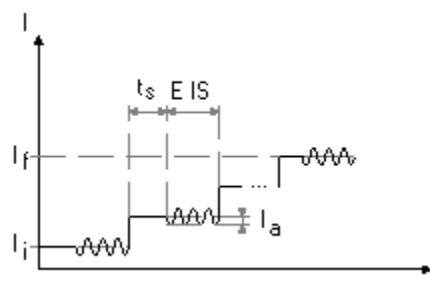


Fig. 36: SGEIS description.

Parameters	Description
Scan from I_i =	0,000 mA Vs. None
to I_f =	0,100 mA Vs. None
with N =	10 current steps
Wait for t_s =	1,000 000 sec
Record every dE =	100,000 mV
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude I_a =	1,000 mA
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	10 mA
Bandwidth =	8
Update	

Fig. 37: SGEIS detailed parameters.

DC current scan

Scan from $I_i = \dots\dots\dots \text{pA/nA}/\dots/A$ vs. None/ I_{init} to $I_f = \dots\dots\dots \text{pA/nA}/\dots/A$ vs. None/ I_{init}

sets the initial and the final current limits for the scan. The limits can be defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

With $N = \dots\dots\dots$ Current steps

defines the number of currents steps between I_i and I_f .

Wait for $t_s = \dots\dots\dots \mu\text{s/ms}/\dots/\text{days}$

applies I for a t_s duration. Set t_s large enough to wait for the cell current stabilization, if the applied potential is different to the open circuit potential. During this period, no impedance measurement is done.

Record every $dE = \dots\dots\dots \text{mV}$ or $dt = \dots\dots\dots \text{s}$

offers the ability to record E_{we} and I during the DC period before the AC simulation with two conditions on the current variation dI and (or) on time variation.

AC measurement

Scan from $f_i = \dots\dots\dots \text{MHz/kHz/Hz/mHz}/\mu\text{Hz}$ to $f_f = \dots\dots\dots \text{MHz/kHz/Hz/mHz}/\mu\text{Hz}$

defines the initial (f_i) and final (f_f) frequencies of the scan. To have more than the first measured point, it is recommended to scan from the highest frequencies to the lowest ones, but it is possible to reverse the frequencies scan order.

With $N_T = \dots\dots\dots$ points

defines the total number of frequency points N_T between the scan bounds f_i and f_f .

Point spacing: Logarithmic or linear

defines the point spacing.

For example, a scan from $f_i = 100 \text{ kHz}$ to $f_f = 1 \text{ kHz}$ with $N_T = 11$ total number of points in linear spacing, will make measurements at these frequencies (Hz):

100, 90, 80, 70, 60, 50, 40, 30, 20, 10, 1.

Sinus amplitude $I_a = \dots\dots\dots \text{pA/nA}/\dots/A$

sets the AC sinus amplitude to I_a . It is added to the DC current level.

Wait for $p_w = \dots\dots\dots$ period before each frequency

offers the ability to add a delay before the measurement at each frequency. This delay is defined as a part of the period. Of course for low frequencies the delay may be long.

Average $N_a = \dots\dots\dots$ measure(s)

repeats N_a measure(s) and average values for each frequency.

Drift correction

function resulting in the correction of the DC level drift. This feature is more especially dedicated to low frequencies.

Note that if this option is selected, the sinus frequencies are evaluated over 2 periods (instead of 1), increasing the acquisition time by a factor of 2.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

4. Pulsed techniques

This chapter describes the pulsed techniques available in EC-Lab[®] Express. As seen in the figure below six pulsed techniques are available in the EC-Lab[®] Express.

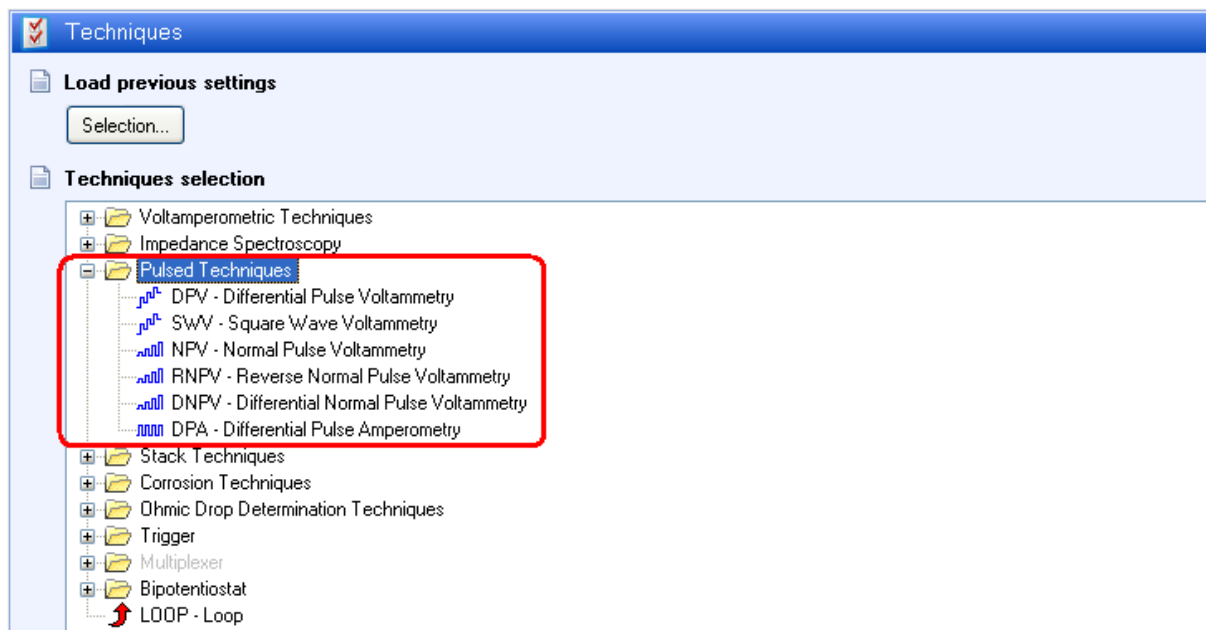


Fig. 38: detailed pulsed techniques.

4.1 DPV: Differential Pulse Voltammetry

DPV is very useful for analytical determination (for example, metal ion quantification in a sample). The differential measurements discriminate faradic current from capacitive one. In this technique, the applied waveform is the sum of a pulse train and a staircase from the initial potential (E_i) to a limit potential (E_l), or to the final potential (E_f) if the scan is reversed. The current is sampled just before the pulse and near the end of the pulse. The resulting current is the difference between these two currents. It has a relatively flat baseline. The current peak height is directly related to the concentration of the electroactive species in the electrochemical cell.

Parameters	Description
Set E_i =	-0,200 000 V Vs. Eref
Rest for t_i =	1,000 000 sec
Scan from E_i to E_f =	0,500 000 V Vs. Eref
with pulse height P_H =	2,5 mV
pulse width P_W =	100 ms
step height S_H =	5,0 mV
step time S_T =	500 ms
Measure I from	80 % of each step
to	100 % of each step
I Range =	10 mA
E Range =	+/-2.5V
Bandwidth =	8
Scan rate = 10 mV/s	
Update	

Fig. 39: DPV detailed parameters.

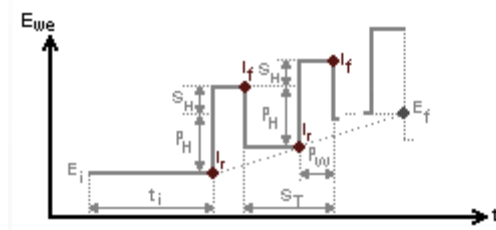


Fig. 40: DPV waveform.

Pulse waveform and potential limits

Set E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for t_i = μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Scan from E_i to E_f = V vs. E_{ref} , E_{oc} , E_{init}

defines the final potential E_f . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

with	pulses height P_H =	mV
	pulses width P_W =	ms
	step height S_H =	mV
	step time S_T =	ms

The pulse train is made of pulses with, pulse height P_H amplitude and pulse width P_W duration, superimposed with a staircase of step height amplitude S_H and step time S_T duration.

Note that only one point is recorded at the end of the potential pulse and one point before, making two points during the S_T period.

The example above (Fig. 39) is given for a positive scan. To perform a negative scan set E_f inferior to E_i .

Measure I from % of each step to % of each step

selects the part of the potential step for the current average ($\langle I \rangle$) calculus, to exclude the first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average and a value of 0 % will take only the last point.

Note that the current average ($\langle I \rangle$) is recorded at the end of the potential step into the data file.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different, and dynamic current range changes may lead to have spikes on the plot.

Indicative information

Scan rate = mV/s

This value is given as an indication and is calculated into the computer. The scan rate is directly given by $S_H / (0.001 S_T)$.

DPV calculated variables:

The variables below are calculated from $\langle I \rangle$ or the potential:

- I forward / mA: $\langle I \rangle$ values at the end of the pulses (I_p),
- I reverse / mA: $\langle I \rangle$ values before the pulses (I_{bp}),
- I delta / μA : difference between $\langle I \rangle$ values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current.

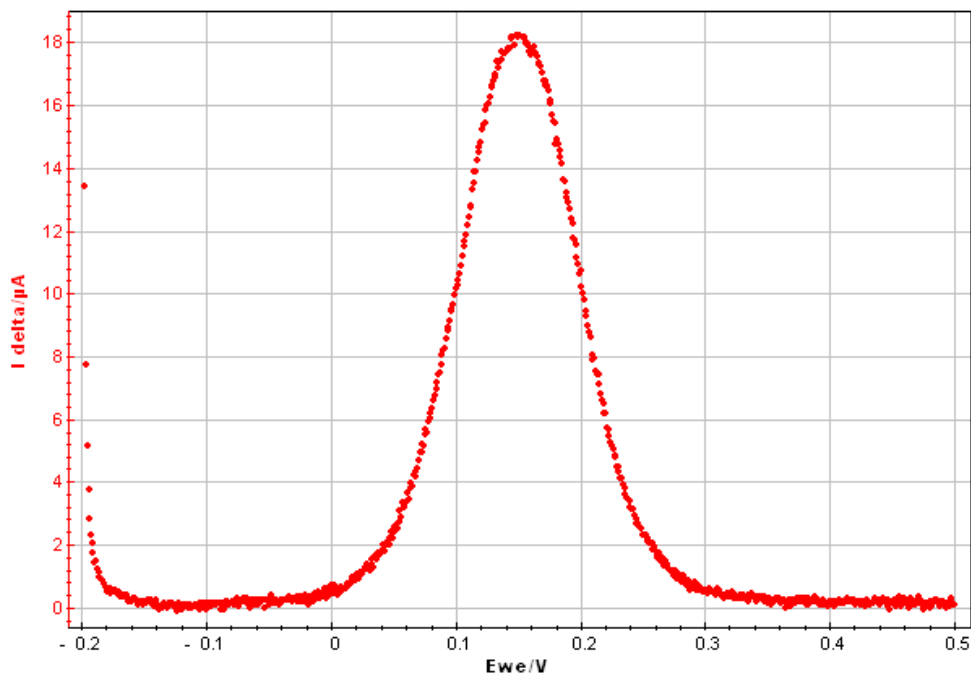


Fig. 41: DPV measurement in a Fe(II) solution.

4.2 SWV: Square Wave Voltammetry

Among the electroanalytical techniques, the Square Wave Voltammetry (SWV) combines the background suppression, the sensitivity of DPV and the diagnostic value of NPV. The SWV is a large amplitude differential technique in which a waveform of a symmetrical square wave (with one pulse in the forward direction and one in the reverse), superimposed on a base staircase potential, is applied to the working electrode. The square wave is characterized by a pulse height (P_H) and a pulse width (P_W). The pulse width can be expressed in terms of square wave frequency $f = 1/(2P_W)$. The scan rate is $v = P_H/(2P_W)$. The current is sampled twice during each square wave cycle, once at the end of the forward pulse and once at the end of the reverse pulse. The difference between the two measurements is plotted versus the base staircase potential. The resulting peak-shaped voltammogram is symmetrical around the half-wave potential and the peak current is proportional to the concentration. Excellent sensitivity accrues from the fact that the net current is larger than either the forward or reverse components (since it is the difference between them).

Parameters	Description
Set E_i =	-0,500 000 V Vs. Eref
Rest for t_i =	1,000 000 sec
Scan from E_i to E_f =	0,500 000 V Vs. Eref
with pulse height P_H =	25,0 mV
pulse width P_W =	50 ms
step height S_H =	10,0 mV
Measure I from	80 % of each step
to	100 % of each step
I Range =	10 mA
E Range =	+/-2.5 V
Bandwidth =	8
Scan rate = 100 mV/s	
Update	

Fig. 42: SWV detailed setup.

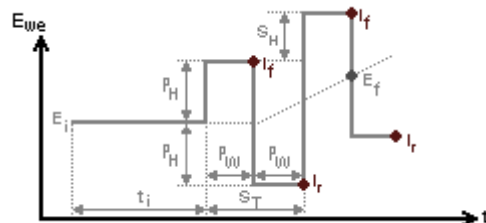


Fig. 43: SWV waveform.

Pulse waveform and potential limits

Set E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for t_i = μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Scan from E_i to E_f = V vs. E_{ref} , E_{oc} , E_{init}

defines the final potential E_f . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

with pulses height P_H = mV
 pulses width P_W = ms
 step height S_H = mV

The pulse train is made of pulses with, pulse height P_H amplitude and pulse width P_W duration around the averaged potential scan. The scan increment is defined by staircases of step height amplitude S_H and step time S_T duration.

Note that only one point is recorded at the end of the potential forward pulse and one point at the end of the potential reverse pulse, making two points during the S_T period.

The settings above (Fig. 42) are given for a positive scan. To perform a negative scan, set E_f inferior to E_i .

Measure I from % of each step to % of each step

selects the part of the potential step for the current average ($\langle I \rangle$) calculus, to exclude the first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average and a value of 0 % will take only the last point.

Note that the current average ($\langle I \rangle$) is recorded at the end of the potential step into the data file.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different and dynamic current range changes may lead to spikes on the plot.

Scan rate = mV/s

This value is given as an indication and is calculated in the computer. The scan rate is directly given by $S_H / (0.001 S_T)$.

SWV calculated variables:

The variables below are calculated from $\langle I \rangle$ or from the potential:

- I forward / mA: $\langle I \rangle$ values at the end of the pulses (I_p),
- I reverse / mA: $\langle I \rangle$ values before the pulses (I_{bp}),
- I delta / μA : difference between $\langle I \rangle$ values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current.

4.3 NPV: Normal Pulse Voltammetry

Pulsed techniques have been introduced to increase the ratio between the faradic and nonfaradic currents in order to permit a quantification of a species to very low concentration levels. The Normal Pulse Voltammetry is one of the first pulsed techniques elaborated for polarography needs. The essential idea behind the NPV is the cyclic renewal of the diffusion layer. With a DME, this is achieved by the stirring accompanying the fall of the mercury drop. But with other electrodes renewal may not be so easily accomplished.

NPV consists of a series of pulses of linear increasing amplitude (from E_i to E_f). The potential pulse is ended by a return to the base value E_i . The usual practice is to select E_i in a region where the electroactive species of interest does not react at the electrode. The current is sampled at a time t near the end of the pulse and at a time t' before the pulse. The plotted current is the difference of both currents measured at the end of the pulse (forward) and at the end of the period previous to the pulse (reverse).

Parameters	Description
Set E_i =	-0,500 000 V Vs. Eref
Rest for t_i =	1,000 000 sec
Scan from E_i to E_f =	0,500 000 V Vs. Eref
with pulse height P_H =	10,0 mV
pulse width P_W =	25 ms
step time S_T =	100 ms
Measure I from	80 % of each step
to	100 % of each step
I Range =	10 mA
E Range =	+/-2.5 V
Bandwidth =	8
<i>Scan rate = 100 mV/s</i>	
Update	

Fig. 44: NPV detailed setup.

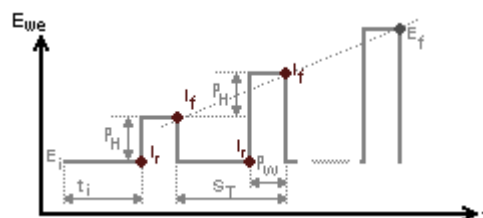


Fig. 45: NPV waveform.

Pulse waveform and potential limits

Set E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for t_i = μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Scan from E_i to E_f = V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_f for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

with pulses height P_H = mV
 pulses width P_W = ms
 step time S_T = ms

The pulse train is made of pulses with a pulse height P_H amplitude that is added to the pulse height of the previous pulse and pulse width P_W duration. After each pulse, the potential always comes back to the initial potential. The scan increment is defined by a pseudo staircase made with steps of amplitude P_H and duration S_T .

Note that only one point is recorded at the end of the potential forward pulse and one point at the end of the potential reverse pulse, making two points during the S_T period.

The settings above (Fig. 44) are given for a positive scan. To perform negative scan, set E_f inferior to E_i and S_H to a negative value.

Measure I from % of each step to % of each step

selects the part of the potential step for the current average (<I>) calculus to exclude first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average, and a value of 0 % will take only the last point.

Note that the current average (<I>) is recorded at the end of the potential step in the data file.

Instruments parameters**I Range =**

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different and dynamic current range changes may lead to spikes on the plot.

Scan rate = mV/s

this value is given as an indication and is calculated in the computer. The scan rate is directly given by $S_H / (0.001 S_T)$.

Indicative information**NPV calculated variables:**

The variables below are calculated from <I> or the potential:

- I forward / mA: <I> values at the end of the pulses (I_p),
- I reverse / mA: <I> values before the pulses (I_{bp}),
- I delta / μ A: difference between <I> values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current.

4.4 RNPV: Reverse Normal Pulse Voltammetry

The Reverse Normal Pulse Voltammetry is a derivative technique from the NPV. The main difference is that the initial (base) potential E_i is placed in the diffusion-limited region for electrolysis of the species present in the bulk solution. The pulses are made through the region where the species in solution are not electroactive. The RPV experiment involves a significant faradic current. This method is a reversal experiment because of the detection of the product from a prior electrolysis.

Parameters	Description
Set E_i =	-0,500 000 V Vs. Eref
Rest for t_i =	1,000 000 sec
Scan from E_i to E_f =	0,500 000 V Vs. Eref
with pulse height P_H =	10,0 mV
pulse width P_W =	25 ms
step time S_T =	100 ms
Measure I from	80 % of each step
to	100 % of each step
I Range =	10 mA
E Range =	+/-2.5 V
Bandwidth =	8
<i>Scan rate = 100 mV/s</i>	
Update	

Fig. 46: RNPV detailed setup.

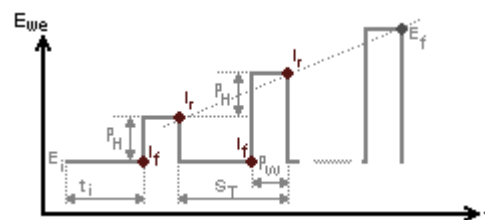


Fig. 47: RNPV waveform.

Pulse waveform and potential limits

Set E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for t_i = μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Scan from E_i to E_f = V vs. E_{ref} , E_{oc} , E_{init}

sets the final potential E_f for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

with pulses height P_H = mV
 pulses width P_W = ms
 step time S_T = ms

The pulse train is made of pulses with pulse height P_H amplitude that is added to the pulse height of the previous pulse and a pulse width P_W duration. After each pulse the potential always comes back to the initial potential. The scan increment is defined by a pseudo staircase made with steps of amplitude P_H and duration S_T .

Note that only one point is recorded at the end of the potential forward pulse and one point at the end of the potential reverse pulse, making two points during the S_T period.

The settings above (Fig. 46) are given for a positive scan. To perform negative scan, set E_i inferior to E_f and S_H to a negative value.

Measure I from % of each step to % of each step

selects the part of the potential step for the current average ($\langle I \rangle$) calculus to exclude the first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average and a value of 0 % will take only the last point.

Note that the current average ($\langle I \rangle$) is recorded at the end of the potential step in the data file.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different and dynamic current range changes may lead to spikes on the plot.

Scan rate = mV/s

This value is given as an indication and is calculated in the computer. The scan rate is directly given by $S_H / (0.001 S_T)$.

RNPV calculated variables:

The variables below are calculated from $\langle I \rangle$ or the potential (to save size on disk):

- I forward / mA: $\langle I \rangle$ values at the end of the pulses (I_p),
- I reverse / mA: $\langle I \rangle$ values before the pulses (I_{bp}),
- I delta / μA : difference between $\langle I \rangle$ values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current.

4.5 DNPV: Differential Normal Pulse Voltammetry

Originally introduced as a polarographic technique (performed at a Dropping Mercury Electrode (DME)), the Differential Normal Pulse Voltammetry is a sensitive electroanalytical technique very close to the DPV technique with a pulsed potential sweep. The potential pulse is swept from an initial potential E_i to a final potential E_f . There are two main differences with the DPV technique. First, the pulse waveform is made with a prepulse (S_H amplitude with P_W duration) before the pulse (P_H amplitude with P_W duration), and second, the potential always comes back to the initial potential (E_i) after the pulsed sequence. E_i is assumed to be the potential where no faradic reaction occurs. The plotted current is the difference of both currents measured at the end of the pulse (I forward) and the end of the prepulse (I reverse). This technique is often used in polarography and by biologists to define the most appropriate potential for the electrochemical detection to a fixed potential with the DPA technique.

Parameters	Description
Set E_i	= -0,200 000 V Vs. Eref
Rest for t_i	= 1,000 000 sec
Scan from E_i to E_f	= 0,600 000 V Vs. Eref
with pulse height P_H	= 10,0 mV
prepulse width PP_W	= 50 ms
pulse width P_W	= 10 ms
step height S_H	= 50,0 mV
step time S_T	= 100 ms
Measure I from	80 % of each step
	to 100 % of each step
I Range	= 10 mA
E Range	= +/-2.5 V
Bandwidth	= 8
Scan rate = 500 mV/s	
Update	

Fig. 48: DNPV detailed setup.

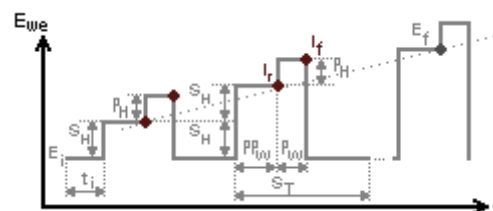


Fig. 49: DNPV waveform.

Pulse waveform and potential limits

Set $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for $t_i = \dots\dots$ μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Scan from E_i to $E_f = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the final potential E_f for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

with

pulses height	$P_H =$	mV
Prepulse width	$PP_W =$	ms
pulse width	$P_W =$	ms
step height	$S_H =$	mV
step time	$S_T =$	ms

The scan increment is defined by a pseudo staircase made with steps of amplitude P_H and duration S_T .

Note that only one point is recorded at the end of the potential forward pulse and one point at the end of the potential reverse pulse, making two points during the S_T period.

The settings above (Fig. 48) are given for a positive scan. To perform negative scan set E_i inferior to E_i .

Measure I from % of each step to % of each step

selects the part of the potential step for the current average ($\langle I \rangle$) calculus, to exclude the first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average and a value of 0 % will take only the last point.

Note that the current average ($\langle I \rangle$) is recorded at the end of the potential step into the data file.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different, and dynamic current range changes may lead to have spikes on the plot.

Scan rate = mV/s

This value is given as an indication and is calculated in the computer. The scan rate is directly given by $S_H / (0.001 S_T)$.

DNPV calculated variables:

The variables below are calculated from $\langle I \rangle$ or from the potential:

- I forward / mA: $\langle I \rangle$ values at the end of the pulses (I_p),
- I reverse / mA: $\langle I \rangle$ values before the pulses (I_{bp}),
- I delta / μA : difference between $\langle I \rangle$ values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current.

4.6 DPA: Differential Pulse Amperometry

The Differential Pulse Amperometry results from the DNPV technique without increasing pulse steps. The potential waveform and the current sampling are the same as for DNPV. A DPA experiment is often used as a sensitive method for the quantification of electrochemical species at a defined potential (E_i). This potential value is often determined with a DNPV experiment (using a potential sweep with the same waveform) previously performed. This technique is dedicated to the quantification of biological electroactive species.

Parameters	Description
Set E_i	= 0,400 000 V Vs. Eref
Rest for t_i	= 1,000 000 sec
Apply waveform with	
prepulse height PP_H	= 50,0 mV
prepulse width PP_W	= 25 ms
pulse height P_H	= 10,0 mV
pulse width P_W	= 10 ms
pulse period P	= 100 ms
for t_p	= 100,000 000 sec
Measure I from	80 % of each step
to	100 % of each step
I Range	= 10 mA
E Range	= +/-2.5 V
Bandwidth	= 8
Update	

Fig. 50: DPA detailed flow diagram.

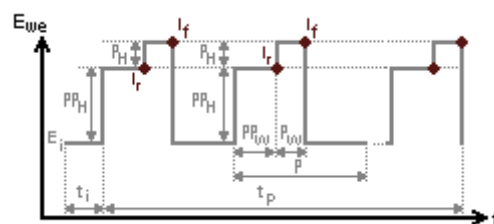


Fig. 51: DPA waveform.

Pulse waveform and potential limits

Set $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Rest for $t_i = \dots\dots$ μ s/ms/.../days

holds the initial potential for a given time to reach stabilization of the electrochemical cell.

Apply waveform

with **Prepulse height $PP_H =$ mV**
 Prepulse width $PP_W =$ ms
 Pulses height $P_H =$ mV
 Pulse width $P_W =$ ms
 Pulse period $P =$ ms

For time period $t_p =$ μ s/ms/.../days

Notice that only one point is recorded at the end of the potential forward pulse and one point at the end of the potential reverse pulse, making two points during the P period.

The pulse train is made of double pulses with pulse height P_H amplitude that is superimposed on the prepulse height PP_H . The prepulse width and the pulse width are defined respectively by PP_W and P_W . After each double pulse sequence, the potential always comes back to the initial potential. This sequence is defined with a period P and is repeated for a time t_p .

Note that only one point is recorded at the end of the potential prepulse and one point at the end of the potential pulse, making two points during the P period.

Measure I from % of each step to % of each step

selects the part of the potential step for the current average ($\langle I \rangle$) calculus to exclude the first points where the current may be perturbed by the step establishment and eventually the last part of the step. A value of 100 % will take all the step points for the average, and a value of 0 % will take only the last point.

Note that the current average ($\langle I \rangle$) is recorded at the end of the potential step in the data file.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: It is highly recommended to not use the automatic current range with pulsed techniques. The resolution of each range is different and dynamic current range changes may lead to spikes on the plot.

DPA recorded and calculated variables:

The variables below are calculated from $\langle I \rangle$ or the potential (to save size on disk):

- I forward / mA: $\langle I \rangle$ values at the end of the pulses (I_p),
- I reverse / mA: $\langle I \rangle$ values before the pulses (I_{bp}),
- I delta / μ A: difference between $\langle I \rangle$ values before and at the end of the pulse ($I_p - I_{bp}$),
- E step / V: step potential value resulting from the potential sweep and used to plot the current. Stack techniques

EC-Lab[®] Express software includes techniques for stack testing. These techniques have been designed to reply to a growing request from customers to perform simultaneous measurements on each element of a stack. The stack can be composed of secondary batteries (such as lithium batteries) or fuel cells. Four different techniques have been made for cycling with a galvanodynamic technique and a potentiodynamic technique and for EIS measurement with a galvanic EIS and a potentiometric EIS technique.

The stack techniques have been improved with respect to the previous version of EC-Lab[®] Express. It is now possible to perform stack experiment on numerous potentiostat channels. the total voltage of the stack must not exceed 20 V and are available only for VMP3 technology (not available for SP-300 technology).

5. STACK techniques

Description of the cable connection to the elements of the stack

The stack techniques require a special set of cables. These cables are provided upon request. The stack techniques are built on a specific control of the instrument with one master channel and several slaves channels. The master one controls the whole stack either in current (GDyn) or potential (PDyn). In most cases, this master channel is coupled with a booster (either in the chassis or external). The slaves measure the potential of each element. One slave channel is able to measure two voltages (two elements) simultaneously. The connection on a stack of 4 elements is described in the scheme below:

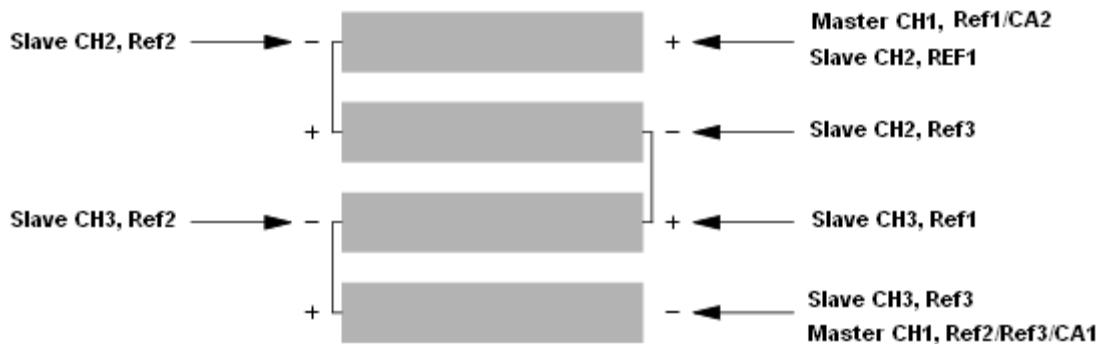


Fig. 52: Cable connection to the elements of a stack.

The master channel is CH1 while CH2 and CH3 are slave channels. The cable connection for the stack is:

- For the master channel cable, five wires are used in a two-electrode connection. At the positive stack electrode, both red cables (Ref1 and CA2) are connected and at the negative electrode, and both blue cables (Ref3 and CA1) are connected with the white one (Ref2).
- For the slave cables, only three wires are used: Ref1, Ref2 and Ref3. Two voltages are measured between Ref2 and Ref1 for the odd elements and between Ref2 and Ref3 for the even elements. Of course the Ref3 cable of a channel is always connected with the Ref1 cable of the following channel.

3 channels are necessary to study a 4-elements stack. For a stack with n elements, $(n/2+1)$ channels are used. Note that for odd numbers, the floor is considered for the channels calculation number. The channel selected in the “Device” frame must be the master channel. The slave channels can be selected at the user’s convenience in the Channel window of the Device window. This window allows the user to settle the master channel and to select the slave channels.

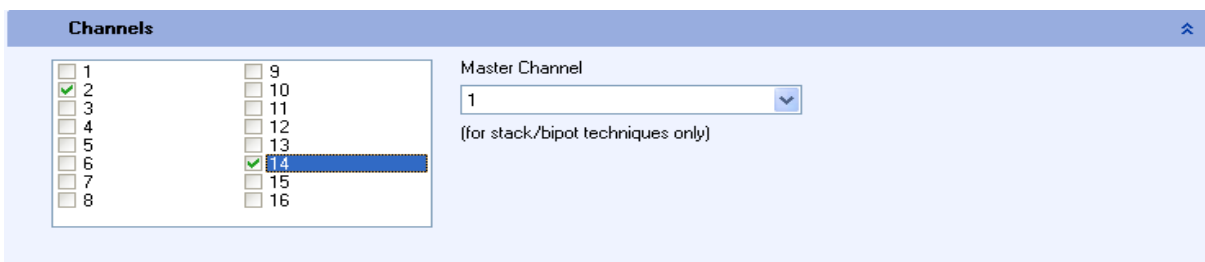


Fig. 53: Master and slave channels selection for stack techniques.

5.1 Stack PDYN: Potentiodynamic measurement on a stack

The Stack potentiodynamic technique allows the user to perform combinations of potentiodynamic periods with different scan rates and different potential vertices. The specific feature of this technique is that the instrument controls the voltage of the whole stack with the master channel while the slave channels measure the potential of each element of the stack simultaneously. Of course, this technique requires several channels to be able to do the measurements. The detailed parameter setup is made as follows:

- potential scan to E_1 ,
- potential sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

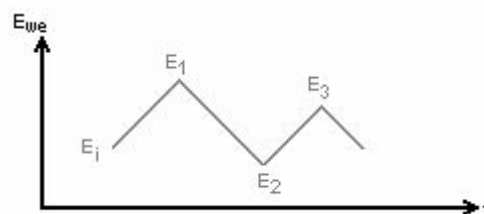


Fig. 54: Stack Potentiodynamic description.

Parameters	Description
Initial Potential E_i	= 0,000 000 V Vs. Eref
Scan with dE/dt	= 100,000 mV/s
Potential E_1	= 1,000 000 V Vs. Eref
+ - 1	
Record every dE	= 100,000 mV
Measure I from	50 % of step
to	100 % of step
Repeat n_c	= 0 times
I Range	= Auto range
Bandwidth	= 5 - Medium speed
Update	

Fig. 55: Stack Potentiodynamic detailed parameters.

Experiment parameters

Initial Potential E_i = V vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Scan with $dE/dt = \dots\dots\dots$ mV/s

sets the current scan rate.

Potential $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

fixes the potential vertex E_1 . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (potential scans) to the experiment with different vertex potential.

Record every $dE = \dots\dots\dots$ mV

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 40 μ s).

Measure I from $\dots\dots\dots$ % of step to $\dots\dots\dots$ % of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current I may be disturbed by the step establishment.

Repeat $n_c = \dots\dots\dots$ times

runs potential scan sequences for n_c times.

Instruments parameters **I Range = $\dots\dots\dots$**

enables the user to select the current range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note:

- In this technique the potential range cannot be adjusted. It is automatically set to 0 V to 20 V,
- in the first sequence the potential scan rate box is not available. The user must define the initial potential from where the scan rate will start in the second sequence.

5.2 Stack GDYN: Galvanodynamic measurement on a stack

The Stack Galvanodynamic technique enables the user to perform combinations of galvanodynamic periods with different scan rates and different current vertices. The specific feature of this technique is that the instrument controls the current of the whole stack with the master channel while the slave channels measure the potential of each element of the stack simultaneously. Of course, this technique requires several channels to be able to do the measurements. The detailed flow diagram is made as follows:

- current scan to I_1 ,
- current sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

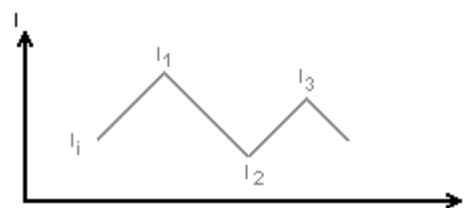


Fig. 56: Stack GDyn description.

Parameters Description

Initial
Current I_i = 2,000 mA vs. None

Scan with dI/dt = 100,000 mA/s

Current I_1 = 4,000 mA vs. None

+ - 1

Record every dI = 100,000 μA

dE = 100,000 mV (slaves only)

Measure E from 50 % of step
to 100 % of step

Repeat n_c = 0 times

I Range = 10 mA

Bandwidth = 5 - Medium speed

Update

Fig. 57: Stack Galvanodynamic detailed parameters.

Experiment parameters

Initial current $I_i = \dots \text{pA/nA}/A$ vs. None/ I_{init}

fixes the initial current I_i . It is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was previously applied, or it can be the last current value measured in the previous technique.

Scan with $dI/dt = \dots \text{pA/s}/A/s$

sets the current scan rate.

Current $I_1 = \dots \text{pA/nA}/A$ vs. None/ I_{init}

fixes the current vertex I_1 . It is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be 0 if no technique was previously applied, or it can be the last current value measured in the previous technique.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (current scans) to the experiment with different vertex currents.

Record every $dI = \dots \text{pA/nA}/A$ vs. None/ I_{init}

allows the user to record only one point every dI variation. If zero is set, all data points will be stored (every 20 μs).

Record every $dE = \dots \text{mV}$ (Slaves only)

allows the user to define a recording condition on the potential variation for the slave channels measuring the elements voltage. If zero is set, all data points will be stored (every 40 μs).

Measure E from $\dots \%$ of step to $\dots \%$ of step

selects the part of each current step (from 1 to 100 %) where the potential is measured and the average calculation will be done, to possibly exclude the first points where the potential may be disturbed by the step establishment.

Repeat n_c = times

runs current scan sequences for n_c times.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note:

- In this technique the potential range cannot be adjusted. It is automatically set from 0 V to 20 V,
- in the first sequence the current scan rate box is not available. The user must define the initial current from where the scan rate will start in the second sequence.

5.3 Stack PEIS: Potentiostatic Impedance on stacks

The SP-50 is not concerned with this section and the following one, as this instrument is not EIS capable.

The Stack PEIS experiment performs impedance measurements on a stack in the potentiostatic mode by applying a sinus around a potential E that can be set to a fixed value or relatively to the cell equilibrium potential. The connection for the master channel and the slaves is described above.

- fixe a DC potential,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.

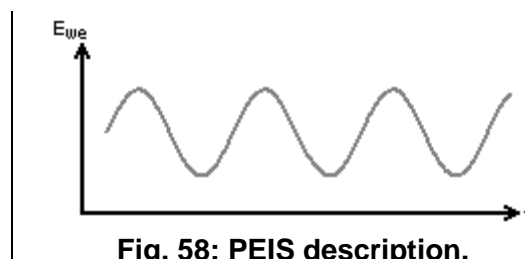


Fig. 58: PEIS description.

The detailed parameter setup is made of:

Parameters	Description
Set E_{we} =	0,000 000 V vs. Eref
Wait for t_s =	1,000 000 sec
Record every dl =	1,000 mA
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude V_a =	10,0 mV
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	<input checked="" type="radio"/> Auto range
Bandwidth =	<input checked="" type="radio"/> 5 - Medium speed
Update	

Fig. 59: Stack PEIS detailed parameters.

Initial DC potential

Set E_{we} = V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Wait for t_s = μ s/ms/.../days

applies E_{we} for a t_s duration. Set t_s large enough to wait for the cell current stabilization, if the applied potential is different to the open circuit potential. During this period, no impedance measurement is done.

Record every dl = pA/nA/.../A or dt = s

offers the ability to record E_{we} and I during the DC period before the AC simulation with two conditions on the current variation dl and (or) on time variation.

AC measurement

Scan from f_i =MHz/kHz/Hz/mHz/ μ Hz to f_f = MHz/kHz/Hz/mHz/ μ Hz

defines the initial (f_i) and final (f_f) frequencies of the scan. To have the first measured point more quickly, it is recommended to scan from the highest frequencies to the lowest ones, but it is possible to reverse the frequencies scan order.

With N_T = points

defines the total number of frequency points N_T between the scan bounds f_i and f_f .

Point spacing: Logarithmic or linear

defines the point spacing.

For example, a scan from $f_i = 100$ kHz to $f_f = 1$ kHz with $N_t = 11$ total number of points in linear spacing will make measurements at these frequencies (Hz):

100, 90, 80, 70, 60, 50, 40, 30, 20, 10, 1.

Sinus amplitude $V_a = \dots V$

sets the AC sinus amplitude to V_a . It is added to the DC potential level.

Wait for $p_w = \dots$ period before each frequency

offers the ability to add a delay before the measurement at each frequency. This delay is defined as a part of the period. Of course for low frequencies, the delay may be long.

Average $N_a = \dots$ measure(s)

repeats N_a measure(s) and average values for each frequency.

Drift correction

function resulting in the correction of the DC level drift. This feature is more especially dedicated to low frequencies.

Note that if this option is selected, sinus frequencies are evaluated over 2 periods (instead of 1), increasing the acquisition time by a factor of 2.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Note: In this technique the potential range cannot be adjusted. It is automatically set to 0 V to 20 V.

5.4 Stack GEIS: Galvanostatic Impedance on stacks

This technique is very close to the Stack Potentiostatic Impedance protocol (Stack PEIS), except that the current is controlled instead of the potential. Therefore, report to the Stack PEIS experiment section for more details.

- fixe a DC current,
- recording condition before frequency scan,
- scan frequencies,
- define amplitude,
- instrument parameters configuration.

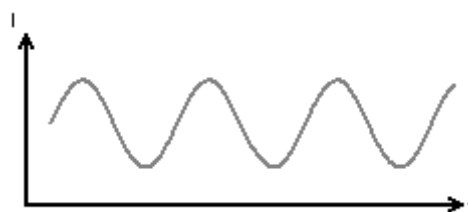


Fig. 60: GEIS description.

Parameters	Description
Set I_s =	0,000 mA Vs. None
Wait for t_s =	1,000 000 sec
Record every dE =	100,000 mV
or dt =	0,100 00 s
Scan from f_i =	100,000 kHz
to f_f =	1,000 Hz
with N_T =	51 points
points spacing =	Logarithmic
sinus amplitude I_a =	1,000 mA
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	10 mA
Bandwidth =	5 - Medium speed
Update	

Fig. 61: Stack GEIS detailed parameters.

Note that the applied current can be defined in absolute (None) or according the initial measured current (I_{init}).

Instead of I_a , one can consider the current peak to peak amplitude (I_{pp}) related to I_a with $I_{pp} = 2I_a$ or the Root Mean Square (RMS) voltage related to I_a with $I_{RMS} = I_a/\sqrt{2}$.

Visualisation of stack impedance data files

EC-Lab[®] Express software provides a display on two separate graphs of the EIS data curves. One graph is for the odd elements of the stack (bottom) and the other one is for the even elements of the stack (top).

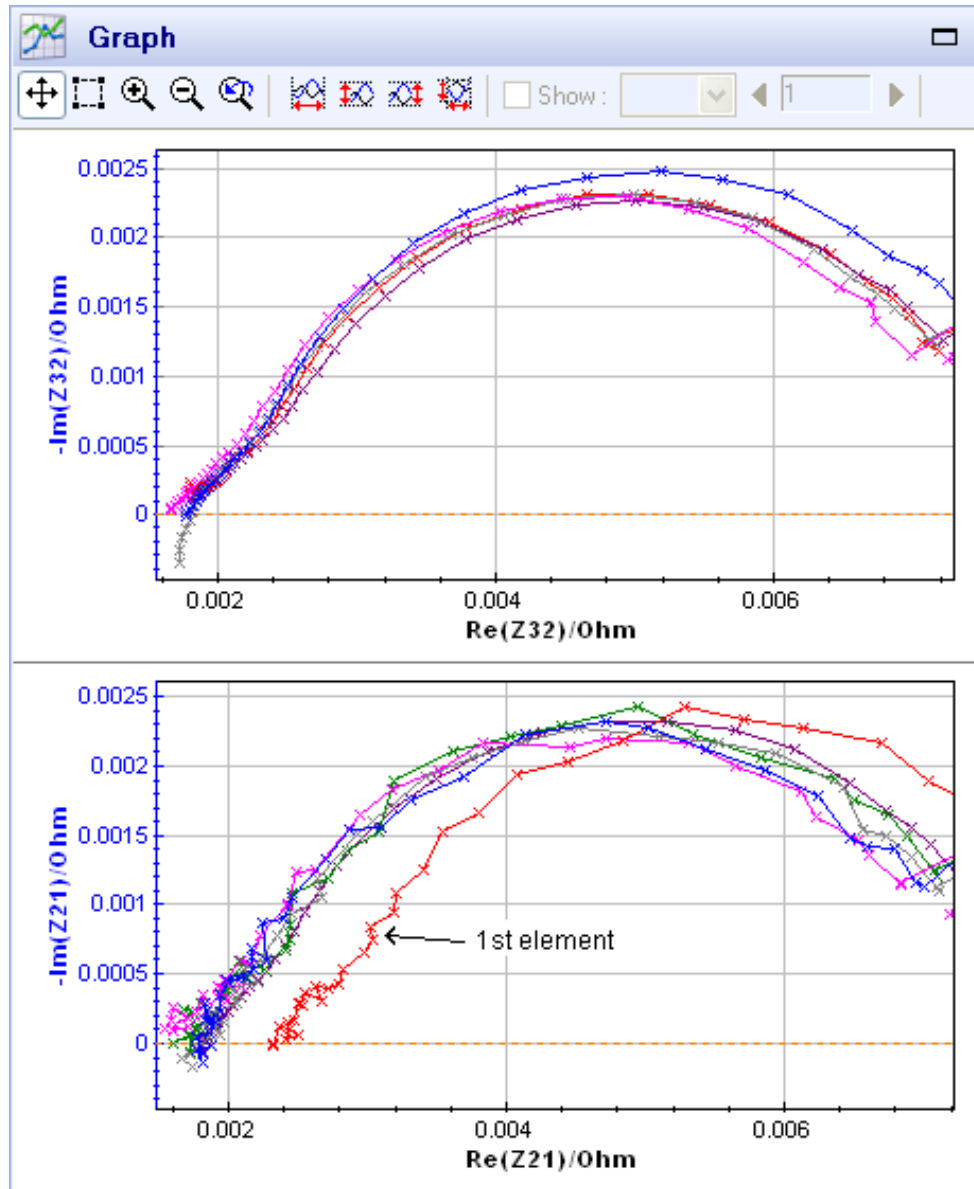


Fig. 62: Plot of a Stack EIS data file.

6. Corrosion techniques

Corrosion is the chemical or electrochemical reaction between a material, usually a metal, and its environment that produces a deterioration of the metal and its properties.

This chapter provides a detailed description of the ten corrosion techniques available with EC-Lab® Express. These techniques are listed in the figure below.

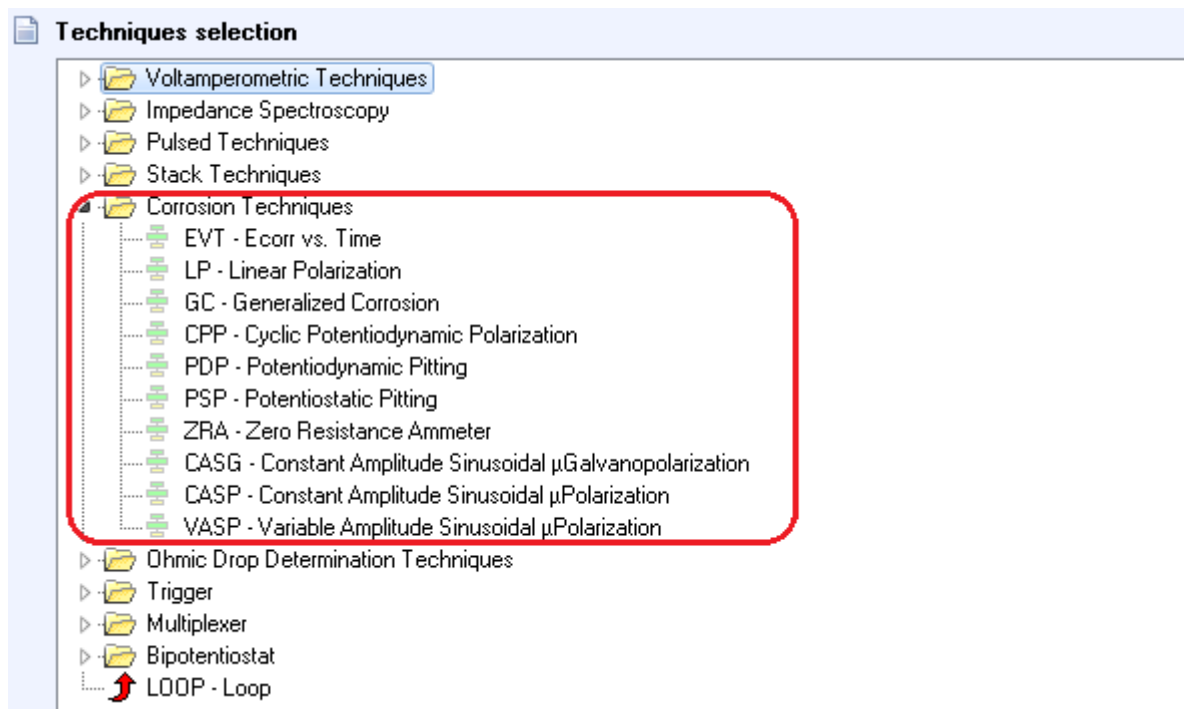


Fig. 63: overview of the corrosion techniques available with EC-Lab® Express.

6.1 EVT: E_{corr} versus Time

This technique corresponds to the follow up of the corrosion potential (when the circuit is open) versus time. During the measurement, no potential or current is applied to the cell.

Parameters	Description
Rest for t_R =	1,000 000 sec
Record every dE_R =	100,000 mV
or dt_R =	0,500 00 s
Update	

Fig. 64: E_{corr} vs. Time setup.

Experiment parameters

Rest for t_R = μs/ms/..../days

fixes a defined time duration t_R for recording the rest potential.

Record every $dE_R =$ mV

or $dt_R =$ s

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R . If zero is set, all data points will be stored (every 20 μ s).

Data recording with dE_R resolution can reduce the number of experimental points without losing any "interesting" changes in potential. When there is no potential change, only points according to the dt_R value are recorded, but if there is a sharp peak in potential, the rate of recording increases.

6.2 LP: Linear Polarization

The linear polarization technique is used in corrosion monitoring. This technique is especially designed for the determination of a polarization resistance R_p of a material and I_{corr} through potential steps around the corrosion potential. R_p is defined as the slope of the potential-current density curve at the free corrosion potential:

$$\lim_{dE \rightarrow 0} \frac{dE}{dl} \Big|_{E=E_{oc}}$$

R_p is determined using the 'R_p fit' graphic tool.

This technique is also used to plot polarization curves and determine corrosion rates and coefficients with the Tafel fit.

Parameters	Description
Rest for $t_R =$	1,000 000 sec
Record every $dE_R =$	100,000 mV
or $dt_R =$	0,500 00 s
Start scan from $E_i =$	-0,025 000 V Vs. Eref
to $E_L =$	0,025 000 V Vs. Eref
with $dE/dt =$	0,167 mV/s
Record every $dE =$	1,000 mV <input checked="" type="checkbox"/> Average
Measure I from	80 % of step
to	100 % of step
I Range =	<input checked="" type="radio"/> Auto range
E Range =	<input checked="" type="radio"/> +/-2.5V
Bandwidth =	<input checked="" type="radio"/> 8
Update	

Fig. 65: Linear Polarization detailed parameters.

Open circuit parameters

Rest for $t_R = \quad \mu\text{s}/\text{ms}/\dots/\text{days}$

fixes a defined time duration t_R for recording the rest potential.

Record every $dE_R = \quad \text{mV}$

or $dt_R = \quad \text{s}$

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Scan parameters

Start scan from $E_i = \dots\dots\dots \text{V}$ vs. E_{ref} , E_{oc} , E_{init}

sets the initial potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

To $E_L = \dots\dots\dots \text{V}$ vs. E_{ref} , E_{oc} , E_{init}

sets the final potential E_f . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

With $dE/dt = \dots\dots\dots \text{mV/s}$

allows the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Record every $dE = \dots\dots\dots \text{mV}$

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 40 μs).

Measure I from $\dots\dots\dots \%$ of step to $\dots\dots\dots \%$ of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done to possibly exclude the first points where the current may be disturbed by the step establishment.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range

E Range = $\dots\dots\dots$

enables the user to select the control potential range

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Related fits to LP

The LP application can be used for R_p and I_{corr} determination using the R_p fit (see the ECLab[®] Express software manual for more details). It can also be used to determine the corrosion rate with the Tafel fit (see the EC-Lab[®] Express software manual for more details).

6.3 GC: Generalized Corrosion

The generalized corrosion protocol is applied for general corrosion (sometimes called uniform corrosion) study. For this corrosion, anodic dissolution is uniformly distributed over the entire metallic surface. The corrosion rate is nearly constant at all locations. Microscopic anodes and cathodes are continuously changing their electrochemical behavior from anode to cathode cells for a uniform attack.

This protocol corresponds to half a cycle or one cycle of usual cyclic voltammetry, with the particularity of a digital potential sweep *i.e.* it runs by potential steps (defined and periodic in amplitude and time). For the VMP3, VMP2, VSP, SP-150, SP-50 and BiStat, the potential step and its duration are defined according to the potential control resolution (see the EC-Lab[®] Express software manual for more details). Then the particular value for the scan rate is 300 mV/min (5 mV/s). Lower scan rates will be obtained with longer step duration whereas higher scan rates can be obtained with higher step amplitudes. If the user specifies a scan rate, the system proposes the closer value that can be obtained with adequate multiples of the potential and time resolutions (100 μ V, 20 ms) or (100 μ V, 10 ms).

In the present version of this application, the results file contains the mean value of the current measured for the whole potential step duration. This mean value is the result of measurements carried out every 2 ms.

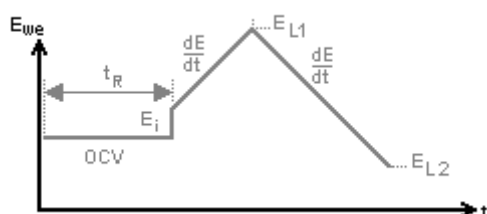


Fig. 66: Waveform of the Generalized Corrosion technique.

Parameters	Description
Rest for t_R	= 1,000 000 sec
Record every dE_R	= 100,000 mV
or dt_R	= 0,500 00 s
Start scan from E_i	= -0,100 000 V Vs. Eref
to E_{L1}	= 0,500 000 V Vs. Eref
End scan to E_{L2}	= 0,000 000 V Vs. Eref
with dE/dt	= 0,167 mV/s
Record every dE	= 1,000 mV <input checked="" type="checkbox"/> Average
Measure I from	80 % of step
to	100 % of step
I Range	= <input checked="" type="radio"/> Auto range
E Range	= <input checked="" type="radio"/> +/-2.5V
Bandwidth	= <input checked="" type="radio"/> 8
<input type="button" value="Update"/>	

Fig. 67: Generalized Corrosion detailed parameters.

Open circuit parameters

Rest for t_R = μ s/ms/.../days

fixes a defined time duration t_R for recording the rest potential.

Record every $dE_R = \quad mV$

or $dt_R = \quad s$

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Scan parameters

Start scan from $E_i = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential E_i for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

To $E_L = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the first vertex potential E_L . It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

End scan to E_{L2}

sets the final potential E_{L2} for the scan. It is defined relative to a reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

With $dE/dt = \dots\dots\dots mV/s$

Allow the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Record every $dE = \dots\dots\dots mV$

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 40 μs).

Measure I from $\dots\dots\dots \%$ of step to $\dots\dots\dots \%$ of step

selects the part of each potential step (from 1 to 100 %) where the current is measured and the average calculation will be done to possibly exclude the first points where the current may be disturbed by the step establishment.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

Related fits to GC

Like the LP, the GC application can be used for R_p and I_{corr} determination using the R_p fit. It can also be used to determine the corrosion rate with the Tafel fit.

6.4 CPP: Cyclic Potentiodynamic Polarization

The Cyclic Potentiodynamic Polarization is often used to evaluate pitting susceptibility. It is the most common electrochemical test for localized corrosion resistance. The potential is swept in a single cycle or slightly less than one cycle. The size of the hysteresis is examined along with the difference between the values of the starting open circuit corrosion potential and the return passivation potential. The existence of hysteresis is usually indicative of pitting, while the size of the loop is often related to the amount of pitting.

This application is based both on the MPP and MPSP protocols, except that the potentiodynamic phase is done before the potentiostatic one, some phases are optional and there is an additional potentiodynamic phase:

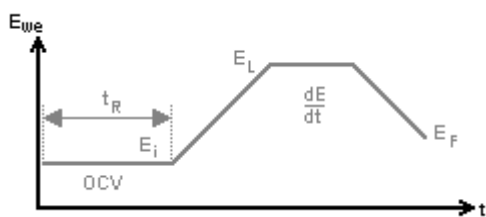


Fig. 68: CPP potential waveform.

The detailed setup is made of:

- initial rest potential sequence,
- potential sweep with threshold pitting detection,
- hold potential,
- reverse scan.

Parameters	Description
Rest for t_R =	1,000 000 sec
Record every dE_R =	100,000 mV
or dt_R =	0,500 00 s
Scan with dE/dt =	0,167 mV/s
Start from E_i =	-0,100 000 V Vs. Eref
to E_L =	0,500 000 V Vs. Eref
or Until $ I > I_p$ =	100,000 μ A
checked after t_b =	0,100 000 sec
(if I_p limit not previously reached)	
<input checked="" type="checkbox"/> Hold E_L Until $ I > I_p$ and	
Record every dt =	0,100 00 s
End scan to E_f =	0,000 000 V Vs. Eref
or until $ I < I_f$ =	0,000 μ A
Record every dE =	10,000 mV <input checked="" type="checkbox"/> Average
Measure I from	80 % of step
to	100 % of step
I Range =	Auto range
E Range =	+/-2.5 V
Bandwidth =	8
Update	

Fig. 69: CPP detailed parameters.

Open circuit parameters

Rest for t_R = μ s/ms/.../days

fixes a defined time duration t_R for recording the rest potential.

Record every dE_R = mV

or dt_R = s

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Scan parameters

Scan with $dE/dt = \dots\dots\dots$ mV/s

allows the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Start from $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential in absolute (vs. your reference electrode potential in the cell) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique.

To $E_L = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the first vertex potential in absolute (vs. your reference electrode potential in the cell) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique.

Or Until $|I| > I_p = \dots\dots\dots$ pA.../A,

fixes the threshold pitting current I_p to detect.

Checked after $t_b = \dots\dots\dots$ μ s/ms/.../days

sets a blanking time t_b enabling the user to skip a possible large current peak when just applying the initial potential step (in case of large ΔE_i value). The check on the pitting current value will be done only after a time t_b .

(if I_p limit not previously reached) Hold E_L Until $|I| > I_p$

If the current limit has not been reached during the previous phase ($|I| \leq I_p$), then the final potential of the scan E_L is held until the current reaches the I_p limit.

Record every $dt = \dots\dots\dots$ s

allows the user to record data points during the holding period. . If zero is set, all data points will be stored (every 40 μ s).

End scan to E_{L2}

sets the final potential in absolute (vs. your reference electrode potential in the cell) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique.

or until $|I| < I_f = \dots\dots\dots$ pA.../A

defines a current limit for the reverse scan. If $|I| < I_f$, then the scan is stopped before the E_{L2} potential is reached.

Record every $dE = \dots\dots\dots$ mV

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 44 μ s for the SP300 technology and every 100 μ s for the VMP3 technology).

Measure I from $\dots\dots\dots$ % of step to $\dots\dots\dots$ % of step

selects the part of each potential step (from 1 to 100 %) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current may be disturbed by the step establishment.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.5 PDP: Potentiodynamic Pitting

Pitting corrosion occurs when discrete areas of a material undergo rapid attack while the vast majority of the surface remains virtually unaffected. The basic requirement for pitting is the existence of a passive state for the material in the environment of interest. Pitting of a given material depends strongly upon the presence of aggressive species in the environment and a sufficiently oxidizing potential. This technique is designed to study pitting corrosion on one or several electrodes together in the electrochemical cell. This technique corresponds to the pitting potential determination of a material using a potential sweep.

First, there is an open circuit sequence with recording of the working electrode potential for a given time or until its variation vs. time is lower than a given limit.

Then, the instrument applies a potential sweep starting either from the potential reached at the end of the open circuit sequence plus a possible offset, or from a given value. The potential sweep goes on until its limit or until the current reaches a value defined as the limit pitting current, and then the working electrode is disconnected.

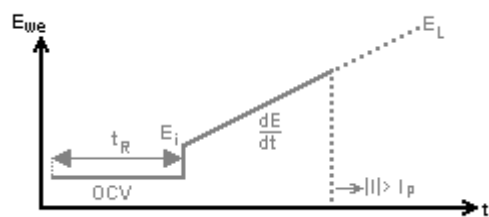


Fig. 70: Potential waveform of the Potentiodynamic Pitting technique.

Parameters	Description
Rest for t_R	<input type="text" value="1,000 000"/> sec
Record every dE_R	<input type="text" value="100,000"/> mV
or dt_R	<input type="text" value="0,500 00"/> s
Start scan from E_i	<input type="text" value="0,000 000"/> V Vs. <input type="text" value="Eref"/>
to E_L	<input type="text" value="0,500 000"/> V Vs. <input type="text" value="Eref"/>
or Until $ I > I_p$	<input type="text" value="50,000"/> μ A
checked after t_b	<input type="text" value="0,500 000"/> sec
with dE/dt	<input type="text" value="0,167"/> mV/s
Record every dE	<input type="text" value="10,000"/> mV <input checked="" type="checkbox"/> Average
Measure I from	<input type="text" value="80"/> % of step
to	<input type="text" value="100"/> % of step
I Range	<input type="radio"/> Auto range
E Range	<input type="radio"/> +/-2.5 V
Bandwidth	<input type="radio"/> 8
<input type="button" value="Update"/>	

Fig. 71: Potentiodynamic Pitting Set up.

Open circuit parameters

Rest for $t_R = \quad \mu\text{s}/\text{ms}/\dots/\text{days}$

fixes a defined time duration t_R for recording the rest potential.

Record every $dE_R = \quad \text{mV}$

or $dt_R = \quad \text{s}$

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Scan parameters

Start scan from $E_i = \dots\dots\dots \text{V}$ vs. $E_{\text{ref}}, E_{\text{oc}}, E_{\text{init}}$

sets the starting potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

To $E_L = \dots\dots\dots \text{V}$ vs. $E_{\text{ref}}, E_{\text{oc}}, E_{\text{init}}$

sets the final potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Or Until $|i| > I_p = \quad \text{pA}/\dots/\text{A}$,

fixes the threshold pitting current I_p to detect. Once the threshold pitting current is reached, the working electrode is disconnected.

Checked after $t_b = \quad \mu\text{s}/\text{ms}/\dots/\text{days}$

sets a blanking time t_b enabling the user to skip a possible large current peak when just applying the initial potential step (in case of large ΔE_i value). The check on the pitting current value will be done only after a time t_b .

Scan with $dE/dt = \dots\dots\dots \text{mV/s}$

allows the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible to an analogic scan.

Record every $dE = \dots\dots\dots \text{mV}$

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 40 μs).

Measure I from $\dots\dots\dots \%$ of step to $\dots\dots\dots \%$ of step

selects the part of each potential step (from 1 to 100 %) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current may be disturbed by the step establishment.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.6 PSP: Potentiostatic Pitting

Pitting corrosion occurs when discrete areas of a material undergo rapid attack while the vast majority of the surface remains virtually unaffected.

The PSP protocol corresponds to studying pitting occurrences under an applied constant potential.

First, there is an open circuit sequence where the working electrode potential is recorded for a given time or until its time variation is lower than a defined limit.

Then, the system applies a constant potential, which can be the potential value reached at the end of the open circuit period plus a given potential offset, or a defined value, until the current reaches a value defined as the pitting current. At the end of the protocol, the working electrode is disconnected.

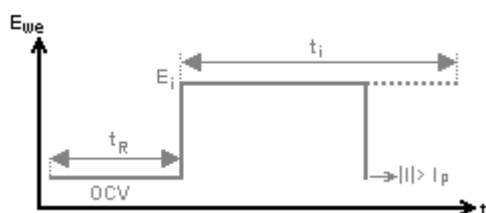


Fig. 72: General description of the Potentiostatic Pitting.

Parameters	Description
Rest for t_R	= 1,000 000 sec
Record every dE_R	= 100,000 mV
or dt_R	= 0,500 00 s
Apply E_i	= 0,200 000 V Vs. Eref
for t_i	= 300,000 000 sec
or Until $ I > I_p$	= 50,000 μ A
checked after t_b	= 0,500 000 sec
Record every dI	= 1,000 μ A
or dt	= 0,500 00 s
I Range	= 100 μ A
E Range	= +/-2.5 V
Bandwidth	= 8
Update	

Fig. 73: Potentiostatic Pitting detailed parameters.

Open circuit parameters

Rest for t_R = μ s/ms/.../days

fixes a defined time duration t_R for recording the rest potential.

Record every dE_R = mV

or $dt_R = \quad s$

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Scan parameters

Apply $E_i = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

For $t_i = \dots\dots\dots \mu s/ms/..../days$

sets the potential step duration.

Or Until $||i| > I_p = \quad \mu A/.../A$,

fixes the threshold pitting current I_p to detect. Once the threshold pitting current is reached, the working electrode is disconnected.

Checked after $t_b = \quad \mu s/ms/..../days$

sets a blanking time t_b enabling the user to skip a possible large current peak when just applying the initial potential step (in case of large ΔE_i value). The check on the pitting current value will be done only after a time t_b .

Record every $dI = \dots\dots\dots \mu A/.../A$ or $dt = \dots\dots\dots s$

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 24 μs).

Measure I from $\dots\dots\dots \%$ of step to $\dots\dots\dots \%$ of step

selects the part of each potential step (from 1 to 100 %) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current may be disturbed by the step establishment.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.7 ZRA: Zero Resistance Ammeter

The Zero Resistance Ammeter is an application for the measurement of galvanic coupling current of dissimilar metals. It is also made to perform some types of electrochemical noise measurement. It consists into applying zero volts between the working electrode (WE) and the counter electrode (CE) and then measuring the current and the potentials (E_{we} , E_{ce}) versus the reference electrode (REF). In most of the cases the coupling current is measured between two identical electrodes. In real situations the electrodes are slightly different resulting in an anodic behavior for one of them and in a cathodic behavior for the other one.

The potential is controlled in this application between Ref1 and Ref3 in the standard connection mode. The first metal must be connected to Ref1+CA2 leads and the other metal must be connected to Ref3+CA1 leads. Ref2 is connected to the reference electrode. It could be necessary to connect the ground lead if the signal is noisy.

First, there is an open circuit sequence where the working electrode potential is recorded for a given time or until its time variation is lower than a defined limit. Then, 0 V is applied between the two electrodes for t_i or until to reach a minimum current value. It is possible to define the recording conditions.

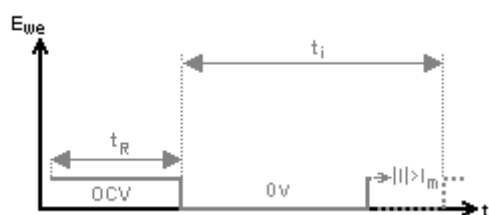


Fig. 74: General description of the Potentiostatic Pitting.

Parameters	Description
Rest for t_R	= 10,000 000 sec
Record every dE_R	= 100,000 mV
or dt_R	= 0,500 00 s
Start ZRA for t_i	= 300,000 000 sec
or Until $ I > I_M$	= 10,000 μ A
checked after t_b	= 0,500 000 sec
Record every dI	= 1,000 μ A
or dt	= 0,500 00 s
I Range	= 100 μ A
E Range	= +/-2.5 V
Bandwidth	= 8
Update	

Fig. 75: Zero Resistance Ammeter detailed parameters.

Open circuit parameters

Rest for t_R = μ s/ms/.../days

fixes a defined time duration t_R for recording the rest potential.

Record every dE_R = mV

or dt_R = s

allows the user to record the working electrode potential whenever the change in the potential is $\geq dE_R$ with a minimum recording period in time dt_R .

Measurement parameters

Start ZRA for t_i = μ s/ms/.../days

sets the potential to 0 V between the both electrodes.

Or Until $|I| > I_M$ = .. pA/nA/.../A

sets the potential step duration.

Checked after t_b $\mu\text{s}/\text{ms}/\dots/\text{days}$

sets a blanking time t_b enabling the user to skip a possible large current peak when just applying the initial potential step (in case of large ΔE_i value). The check on the pitting current value will be done only after a time t_b .

Record every $dI = \dots\dots \text{pA}/\text{nA}/\dots/\text{A}$ or $dt = \dots\dots \text{s}$

allows the user to record only one point every dE variation. If zero is set, all data points will be stored (every 40 μs).

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.8 CASG: Constant Amplitude sinusoidal micro-Galvanopolarisation

Constant Amplitude Sinusoidal micro Galvano polarization (CASG) is a technique performed on an electrochemical system by applying a current perturbation at a fixed frequency f_s . The perturbation is performed around an initial current (I_i) with a small amplitude (I_a) and a constant low frequency (f_s). Thanks to a Direct Fourier Transform the amplitudes of the fundamental frequency (f_s), 1st ($2 f_s$) and 2nd ($3 f_s$) harmonics are determined. This technique can also be used for other applications such as battery, fuel cell, ...

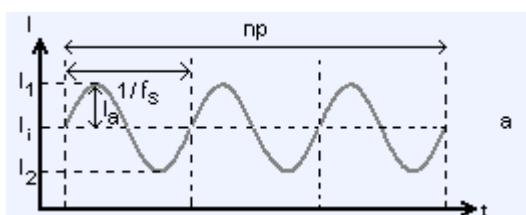


Fig. 76: General description of the CASG technique.

Parameters	Description
$I_i =$	0,000 A Vs. None
$f_s =$	1,000 Hz
Amplitude $I_a =$	0,500 mA Vs. None
$n_p =$	3 times
Record every $dE =$	100,000 mV
or $dt =$	0,010 00 s
+ - 1	
Repeat $n_c =$	0 times
I Range =	Auto range
E Range =	+/-2.5 V
Bandwidth =	8
Update	

Fig. 77: CASG detailed parameters.

Experiment parameters

Initial Current $I_i = \dots\dots\dots$ pA/nA/..A vs. None/ I_{init}

fixes the initial current I_i . It is defined in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

$f_s = \dots\dots$ MHz/kHz/Hz/mHz/ μ Hz

allows the user to set the value of frequency which will define the scan rate.

Amplitude $I_a = \dots\dots\dots$ pA/nA/..A vs. None/ I_{init}

The amplitude of the applied current is defined either in absolute (None) or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

Repeat $n_c = \dots\dots\dots$ times

runs CASG technique between E_1 and E_2 for n_p times

Record every $dE = \dots\dots$ mV or $dt = \dots\dots$ s

offers the possibility to record I with two conditions on the potential variation dE and (or) on time variation. If set to zero, all data points will be stored (every 50 μ s).

Repeat $n_c = \dots\dots\dots$ times

repeats all the sequences n_c times.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.9 Constant Amplitude Sinusoidal microPolarization (CASP)

Constant Amplitude Sinusoidal micro Potentio Polarization (CASP) is a technique used to determine the corrosion current and the Tafel coefficients. In this technique, a sinusoidal voltage is applied around a potential (E_i) with a small amplitude (V_a) and a constant low frequency (f_s). Thanks to a Direct Fourier Transform, the amplitudes of the fundamental frequency (f_s), 1st ($2 f_s$) and 2nd ($3 f_s$) harmonics are determined and used to calculate the corrosion current and the Tafel coefficients. This technique was designed to be faster than the usual linear polarization around the corrosion potential and, compared to the Tafel fit, does not require an adjustment of the Tafel parameters to have access to I_{corr} .

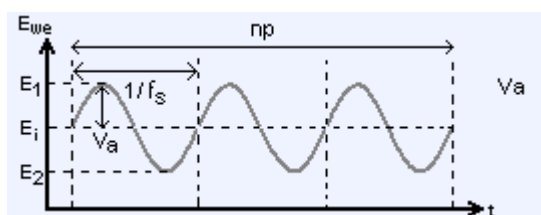


Fig. 78: General description of the CASP technique.

Parameters	Description
E_i	0,000 000 V Vs. Eref
f_s	1,000 Hz
Amplitude V_a	1,000 000 V Vs. E_i
n_p	3 times
Record every dl	0,100 A
or dt	0,010 00 s
Repeat n_c	0 times
I Range	Auto range
E Range	+/-2.5 V
Bandwidth	8
Update	

Fig. 79: CASP detailed parameters.

Experiment parameters

Initial potential $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

$f_s = \dots$ MHz/kHz/Hz/mHz/ μ Hz

allows the user to set the value of frequency which will define the scan rate.

Amplitude $V_a = \dots$ V vs. E_{ref} , E_{oc} , E_{init}

The amplitude of the applied current is defined either in absolute (E_{ref}) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Repeat $n_p = \dots$ times

runs CASP technique for n_p times in each sequence.

Record every $dl = \dots$ pA/nA/..A or $dt = \dots$ s

offers the possibility to record I with two conditions on the potential variation dE and (or) on time variation. If set to zero, all data points will be stored (every 50 μ s).

Repeat $n_c = \dots$ times

repeats all the sequences n_c times.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

6.10 Variable Amplitude Sinusoidal microPolarization (VASP)

Variable Amplitude Sinusoidal micro Polarization (VASP) is a non linear EIS technique used as a corrosion technique to determine the corrosion current and the Tafel parameters. In this technique (only available on potentiostat board with EIS capability) a potential sinusoidal wave is applied around the corrosion potential (E_{corr}) with N amplitudes increasing from V_{amin} to V_{amax} . For each amplitude, the polarization resistance (R_p) is determined and R_p versus applied potential amplitude is plotted. A parametric identification is done on the curve in order to determine the corrosion current and the Tafel parameters.

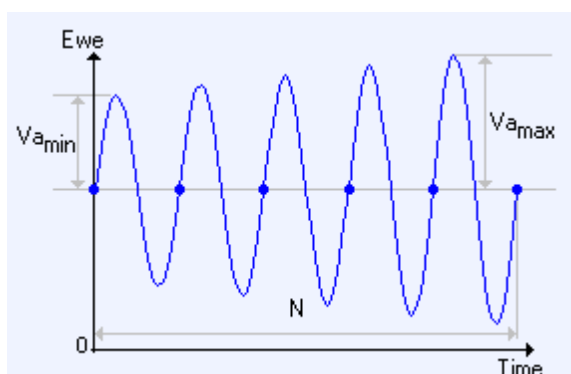


Fig. 80: General description of the VASP technique.

Parameters	Description
Set E_{we} =	0,000 000 V vs. Eref
Wait for t_s =	0,000 000 sec
Record every dl =	1,000 mA
or dt =	0,100 00 s
At f_i =	0,100 Hz
from $V_{a\ min}$ =	5,000 mV
to $V_{a\ max}$ =	50,000 mV
with N =	10 points
wait for p_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
drift correction	<input type="checkbox"/>
I Range =	Auto range
Bandwidth =	8
Update	

Fig. 81: VASP detailed parameters.

Initial DC parameters

Set E_{we} = V vs. E_{ref} , E_{oc} , E_{init}

sets the potential to a fixed value E (vs. Ref, the reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or relatively to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

Wait for t_s = μ s/ms/.../days

applies E_{we} for a t_s duration. Set t_s large enough to wait for the cell current stabilization, if the applied potential is different to the open circuit potential. During this period, no impedance measurement is done.

Record every dl = nA/ μ A/mA/A or dt = s

offers the ability to record E_{we} and I during the DC period before the AC simulation with two conditions on the current variation dl and (or) on time variation.

AC measurement

f_s = MHz/kHz/Hz/mHz/ μ Hz

allows the user to set the value of frequency which will define the scan rate.

from $V_{a\ min}$ = V vs. E_{ref} , E_{oc} , E_{init}

Sets the minimum value of the amplitude of the applied potential from $V_{a\ min}$. This value is settled according the reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

to $V_{a\ max}$ = V vs. E_{ref} , E_{oc} , E_{init}

Sets the maximum value of the amplitude of the applied potential from $V_{a \text{ max}}$. This value is settled according the reference electrode (E_{ref}) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique (E_{init}). E_{init} can be E_{oc} if no technique was previously applied or it can be the last potential value measured in the previous technique.

With N=.....points

Defines the number of the measurement points

Average N_a = measure(s)

repeats N_a measure(s) and average values.

Drift correction

function resulting in the correction of the DC level drift. This feature is especially dedicated to low frequencies.

Note that if this option is selected, the sinus frequencies are evaluated over 2 periods (instead of 1), increasing the acquisition time by a factor of 2.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation

7. Ohmic Drop Determination

Ohmic Drop Determination techniques are used to determine and/or compensate the resistance R_u between the reference electrode and the working electrode when the current is flowing through.

The ohmic drop is the voltage drop developed across the solution resistance R_u between the reference electrode and the working electrode when the current is flowing through. It is a critical parameter that can be significant when experiments are made in non-aqueous media. It may lead to severe distortion of the voltammetric response. Indeed, when the product IR_u gets significant it introduces an important error in the control of the working electrode potential and should be compensated.

7.1 MIR: Manual IR

In controlled potential techniques, the Manual IR (MIR) can be used to compensate the ohmic drop when the uncompensated solution resistance value (R_u) is known or measured before the experiment start. Note that this technique will not measure R_u . Nevertheless, the user can select the compensation percentage. It is highly recommended to not exceed 85% of the R_u measured value to avoid oscillations of the instrument. When used with linked techniques and loops, this technique allows the user to keep the same R_u value for each loop. Note that this technique has to be the first one in a series to compensate the value in the following experiments.

The screenshot shows a software interface for setting Manual IR parameters. It features a 'Parameters' tab and a 'Description' tab. Under the 'Parameters' tab, there are three main settings:

- 'Set R_u = 0,000 Ω': A text input field with a numerical value of 0,000 and a unit symbol Ω.
- 'Compensate at 85 %': A text input field with a numerical value of 85 and a unit symbol %.
- 'Compensation mode': A dropdown menu currently showing 'Soft' with a green circular icon to its left.

 An 'Update' button is positioned at the bottom right of the parameter area.

Fig. 82: Manual IR detailed parameters.

Parameters

Set R_u = Ω

sets the resistance R_u which is already known.

Compensate at ... %

defines the compensation percentage of the R_u resistance. Note that it is recommended that this value does not exceed 85% to avoid instrument oscillations.

7.2 PZIR: IR determination with Potentio Impedance Spectroscopy

IR determination with Potentiostatic Impedance (PZIR) technique utilizes Impedance measurements to determine the R_u value. This technique applies a sinusoidal excitation around the DC potential measured at the beginning of the technique. PZIR technique determines the solution resistance R_u , for one high frequency value, as the real part of the

measured impedance. A percentage of the R_u value will be used to compensate next potentiostatic techniques. As previously, it is highly recommended to not exceed 85% of the R_u measured value in order to avoid oscillations of the instrument.

This technique is very close to the Potentiostatic Impedance protocol (PEIS), except that the EIS measurement is made for only one frequency (choice of the frequency can be done by the user). So report to the PEIS experiment section for more details.

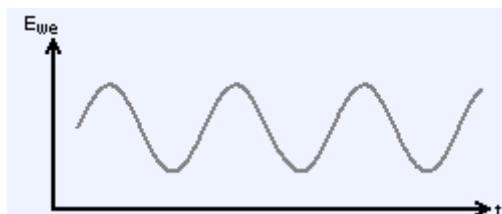


Fig. 83: Sinusoidal excitation around DC potential.

When used in linked techniques including loops, R_u value can change during the experiment. Note that PZIR technique can be an ideal tool to do a dynamic ohmic drop compensation between repeated techniques.

For low impedance electrochemical systems it is recommended to use GZIR instead of PZIR.

Parameters	Description
Measure R_u at f =	100,000 kHz
sinus amplitude V_a =	10,0 mV
wait for P_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
Compensate at	85 %
Compensation mode	<input checked="" type="radio"/> Soft
I Range =	<input checked="" type="radio"/> Auto range
Bandwidth =	<input checked="" type="radio"/> 8
Update	

Fig. 84: PZIR detailed setup.

Parameters

Measure R_u at f = ... MHz/kHz/Hz/mHz/ μ Hz

defines the frequency to measure the resistance.

sinus amplitude V_a = ... mV

defines amplitude of sinusoidal excitation.

wait for P_w = ... period(s) before each frequency

defines the inactivity period between each frequency measurement.

average N_a = ... measure(s)

repeats N_a measure(s) and average values.

Compensate at ... %

defines the level of the measured uncompensated resistance R_u that will be compensated to define IR.

Instruments parameters**I Range =**

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

7.3 GZIR: IR determination with Galvanostatic Impedance

IR determination with Galvanostatic Impedance (GZIR) technique (available on potentiostat board with EIS ability) utilizes Impedance measurements to determine the R_u Value. This technique applies a sinusoidal excitation around the DC current measured at the beginning of the technique. GZIR technique determines the solution resistance R_u , for one high frequency value, as the real part of the measured impedance. A percentage of the R_u value will be used to compensate next potentiostatic techniques. As previously, it is highly recommended to not exceed 85% of the R_u measured value in order to avoid oscillations of the instrument.

This technique is very close to the Potentiostatic Impedance protocol (GEIS), except that the EIS measurement is made for only one frequency. So report to the PEIS experiment section for more details.

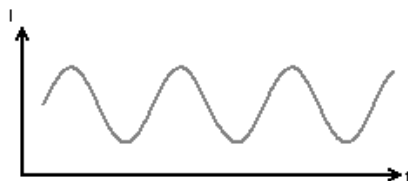


Fig. 85: Sinusoidal excitation around DC current.

In the case of particular non-linear systems it can be necessary to use PZIR instead of GZIR.

Parameters	Description
Measure R_u at f =	100,000 kHz
sinus amplitude I_a =	1,000 mA
wait for P_w =	0,10 period(s) before each frequency
average N_a =	1 measure(s)
Compensate at	85 %
Compensation mode	Soft
I Range =	10 mA
Bandwidth =	8
Update	

Fig. 86: GZIR detailed setup.

Parameters

Measure R_u at f = ... MHz/kHz/Hz/mHz/ μ Hz

defines the frequency to measure the resistance.

sinus amplitude V_a = ... A/mA/ μ A/nA/pA

defines amplitude of sinusoidal excitation.

wait for P_w = ... period(s) before each frequency

defines the inactivity period between each frequency measurement.

average N_a = ... measure(s)

repeats N_a measure(s) and average values.

Compensate at ... %

defines the level of the measured uncompensated resistance R_u that will be compensated to define IR.

Instruments parameters

I Range =

enables the user to select the current range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

7.3.1 Compensation mode hardware vs software

IR drop compensation is an adjustment feature

7.3.2 Ohmic drop compensation

Two ohmic drop compensation are offered by EC-Lab Express: a software compensation using the MIR technique and a hard ohmic drop compensation using Analog Scan Generator for high scan rate.

8. Triggers

Selecting the triggers option allows the user to insert a trigger command before or after a technique. The way to proceed is the same as for linked techniques. Two options are available: the trigger in and the trigger out. The next table summarizes the different possibilities for the trigger in and out:

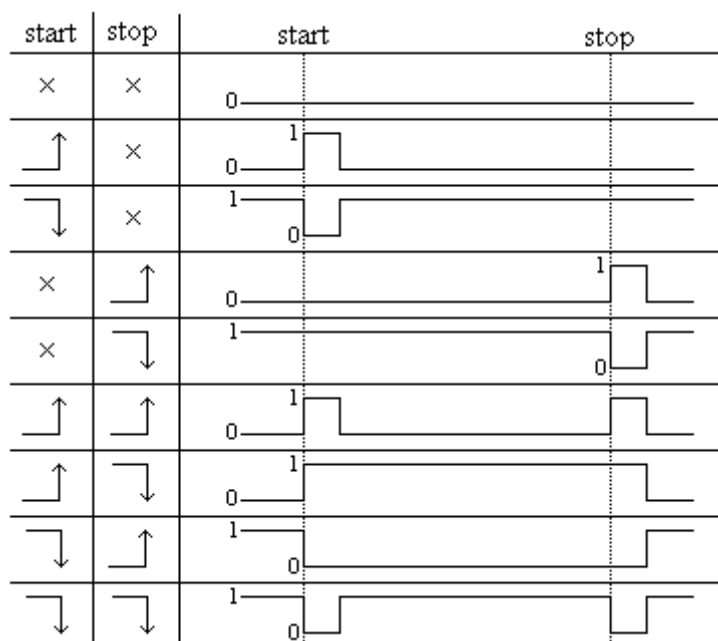


Fig. 87: Triggers in and out.

Three trigger techniques are available with EC-Lab Express:

8.1 Trigger out: TO

The 'Trigger Out' technique can be used to synchronize a potentiostat channel with an external instrument.

The trigger Out option send a trigger (TTL logic signal) to an external instrument with a high level (or low level) before or after a technique. It is possible to select the duration of the Trigger Out. Inserting the trigger before or after the technique will start or stop the run. These features can be set for every technique of the experiment.

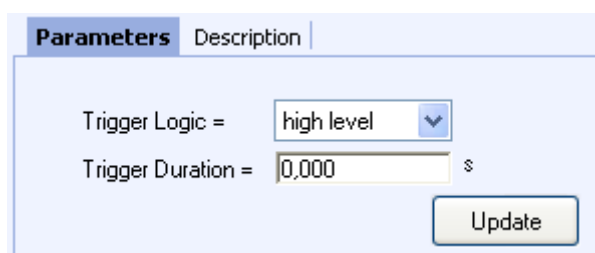


Fig. 88: Trigger Out technique setup.

8.2 Trigger in: TI

The trigger In option will put the instrument in a waiting configuration until it receives a trigger with high level (or low level) depending on the instrument that generates the trigger signal. The potentiostat waits an external trigger to continue the experiment with the technique set after the 'Trigger In' technique. Before receiving the trigger the potentiostat goes to the next technique control mode. The trigger in signal is level sensitive and can be set to be either logic low or high. For the potentiostat to recognize the trigger a pulse must be set and held for a minimum of 100 μ s.

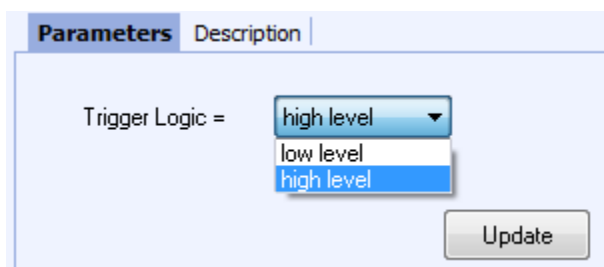


Fig. 89: Trigger In technique setup.

8.3 Trigger set: TOS

The 'Trigger Out Set' technique can be used together with the 'Trigger Out' technique to synchronize the potentiostat with an external instrument. 'Trigger Out Set' technique sets the default level of the trigger out signal to be either at a logic low or high level. Before and after a pulse generated by the 'Trigger Out' technique the potentiostat drives the trigger out signal to the default level. The trigger out default level can be changed only by another execution of a 'Trigger Out Set' technique or by a power-up or reset of the potentiostat

The technique TOS is necessary to activate the Trigger Out when the High level is considered. Indeed two positions in potential are available in the TOS technique:

- 0 corresponding to 0 V,
- 1 corresponding to 5 V.

Indeed by default the value of the trigger out is 0, whereas for a low level the initial value has to be set to 1.

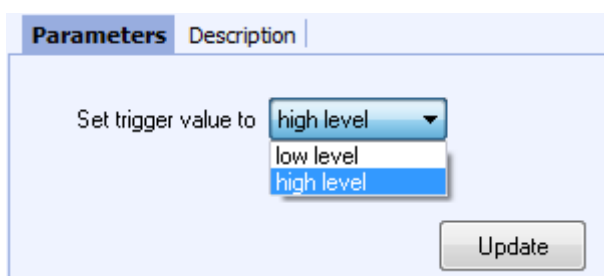


Fig. 90: Trigger In technique setup.

The triggers are available on the DB9 connector as described below (more information in the manual of the installation and configuration of the instrument):

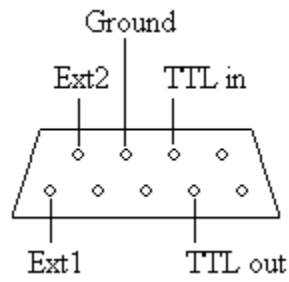


Fig. 91: DB9 Pin assignment.

A special cable made with a DB9 connector on one side and 8 BNC plugs on the other side is provided with the instrument under request.

9. Multiplexer

To perform investigations on Multi Electrode Array (MEA) with the MP-MEA multiplexer, a dedicated technique is offered in EC-Lab[®] Express *i.e.* “Mux” technique. This technique allows the user to select the MEA Matrix configuration among several MEA designs. It controls the order of the electrode multiplexing process on the MP-MEA.

The MUX technique is only displayed in the list of the available techniques if the MP-MEA is connected to the potentiostat. (or if no device is connected to EC-Lab[®] Express).

Here is the procedure to set an experiment with MP-MEA.

1 – In the technique window, Select MUX technique, the following window appears with “MUX” and “MUX loop” techniques in the “Experiment” browser:

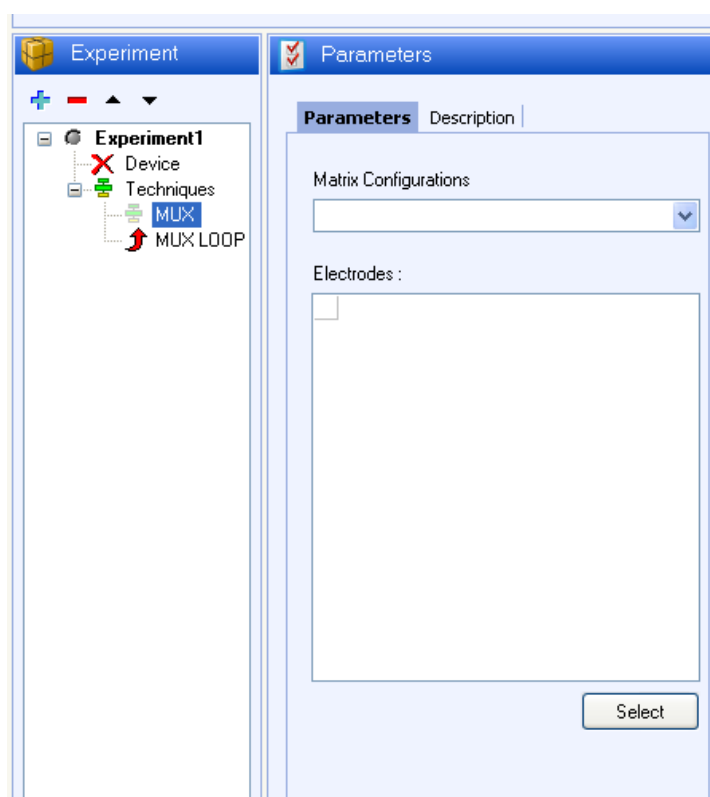


Fig. 92: Experiment and MUX technique frame.

2 - Select the MEA shape via the combo box “Matrix Configurations” on the top of the window showing the “MUX” technique, then an overview of the MEA is displayed in the “Electrodes” block.

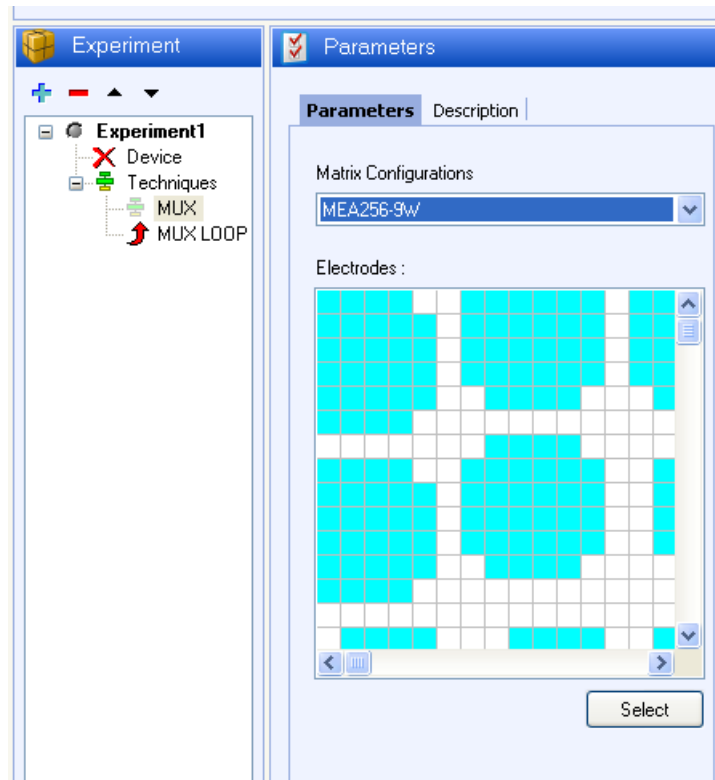


Fig. 93: MEA selection.

3 - To select the electrode of interest, click on the “Select” button. The “Electrodes selection” window appears. Selection is done by left click on the mouse. To validate the electrode selection, user has to click on the “OK” button.

Note:

- It is possible to select a block of electrode with “Shift” + the left-click on the mouse and sequential selection with “Ctrl” + left click on the mouse.
- It is not possible to modify the MEA shape and the selected electrodes when the experiment is running.

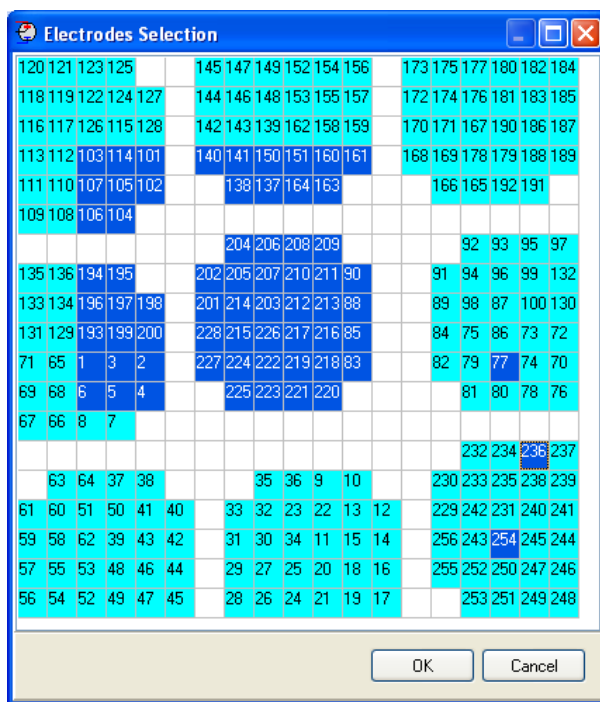


Fig. 94: Electrodes selection.

4 - Then, the user can select one or several electrochemical techniques available in EC-Lab[®] Express software.

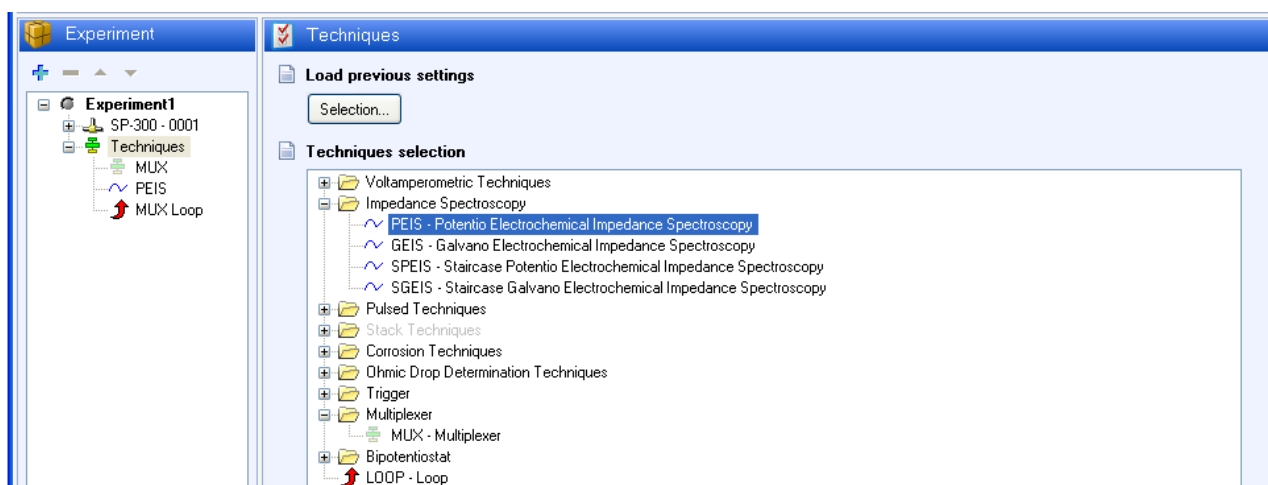


Fig. 95: technique selection.

Note:

- If several techniques are selected, all the electrochemical techniques are performed one after the other on the first electrode, and in the next step all the electrochemical techniques are performed on the new electrode and so on.
- Measurement is done first on the electrode with the lowest PAD number and continues in ascending order.

10. Bipot

One of the most popular applications of multichannel potentiostat (Bistat, VSP, VMP2, VMP3, SP-300) in the fundamental electrochemistry is the bipotentiostat experiment. This kind of experiment consists in applying two synchronized techniques on two electrodes (one technique on each electrode). This is the case of the Rotating Ring-Disk Electrode (RRDE) or hydrogen permeation investigations. In order to make easier the set-up, dedicated couple of techniques such as CV/CA, CP/CA, CA/CA are offered in EC-Lab[®] Express.

Note:

- both channel are totally independent, but the first technique control the sampling rate and the total duration of the experiment, that's why this channel board is called "master". It has to be selected and defined in the "**Device**" window, "**Channel**" frame.
- this technique is only available in the "advanced interface" mode.

10.1 CV_CA : CV synchronized with CA

The technique is composed of CV on the "master" channel and a CA on the other channel. Both protocols are displayed in the same technique.

CV block:

- a starting potential E_i ,
- two vertex potentials E_1 and E_2 ,
- a final potential E_f ,
- scan rate definition,
- recording conditions,
- repeat option,
- instrument parameters configuration.

CA block:

- potential step,
- recording conditions,
- instrument parameters configuration.

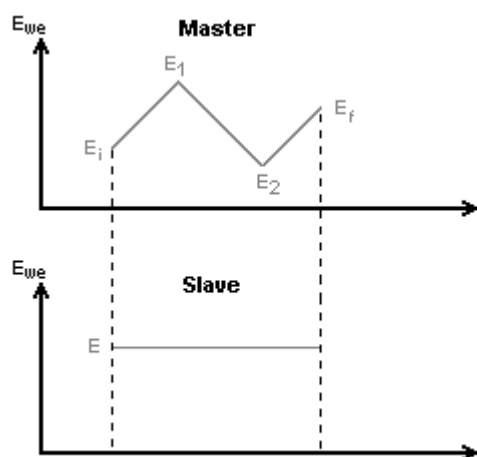


Fig. 96: CV_CA description.

The detailed parameter setup is displayed on the following picture. In this mode, setups of both techniques are displayed in the same frame vertically, the master being displayed at the top and the slave at the bottom.

Parameters	Description
CV Master	
Initial Potential E_i =	0,000 000 V Vs. Eref
Vertex Potential E_1 =	1,000 000 V Vs. Eref
Vertex Potential E_2 =	-1,000 000 V Vs. Eref
Repeat n_c =	0 times
Scan rate dE/dt =	100,000 mV/s
Record every dE =	10,000 mV <input checked="" type="checkbox"/> Average
Measure I from	50 % of step
to	100 % of step
Repeat n_c =	0 times
I Range =	<input checked="" type="radio"/> Auto range
E Range =	<input checked="" type="radio"/> +/-2.5 V
Bandwidth =	<input checked="" type="radio"/> 8
CA Slave	
Apply E =	1,000 000 V Vs. Eref
Record every dt =	0,100 00 s
<input type="checkbox"/> or dl =	0,000 A
I Range =	<input checked="" type="radio"/> Auto range
E Range =	<input checked="" type="radio"/> +/-2.5 V
Bandwidth =	<input checked="" type="radio"/> 8
Update	

Fig. 97: CV_CA detailed setup.

- CV block:**

Experiment parameters

Initial potential $E_i = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the starting potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential (E_{init}). E_{init} can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique.

Vertex potential $E_1 = \dots\dots\dots$ V vs. E_{ref} , E_{oc} , E_{init}

sets the first vertex potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential (E_{init}). E_{init} can

be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique

Vertex potential $E_2 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the second vertex potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential (E_{init}). E_{init} can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique

Final potential $E_f = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

sets the final potential in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential (E_{init}). E_{init} can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique

Scan with $dE/dt = \dots\dots\dots mV/s$

allows the user to set the scan rate in mV/s. The potential step height and its duration are optimized by the software in order to be as close as possible as an analogic scan.

Record every $dE = \dots\dots\dots mV$

allows the user to record only one point every dE variation. If set to zero, all data points will be stored (every 50 μs).

Average

if this box is ticked, an average on the potential is done every dE previously defined.

Measure I from $\dots\dots\dots\%$ of step to $\dots\dots\dots\%$ of step

selects the part of each potential step (from 1 to 100%) where the current is measured and the average calculation will be done, to possibly exclude the first points where the current may be disturbed by the step establishment.

Repeat $n_c = \dots\dots\dots$ times

runs cyclic voltammetry between E_1 and E_2 for n_c times

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

- **CA block:**

Experiment parameters

Apply $E = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

the applied potential is defined in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was applied before, or it can be the last potential value measured in the previous technique.

Record I every $dt = \dots\dots s$ (or $dI = \dots\dots pA/\dots/A$; optional)

The dt condition is calculated according to the condition set in the CV block.
dl can be selected but if dl is reached only data of the CA channel is recorded.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

10.2 CP_CA : CP synchronized with CA

The technique is composed of a CP on the “master” channel and a CA on the other channel. Both protocols are displayed in the same technique.

CP block:

- current step,
- current sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

CA block:

- potential step,
- recording conditions,
- instrument parameters configuration.

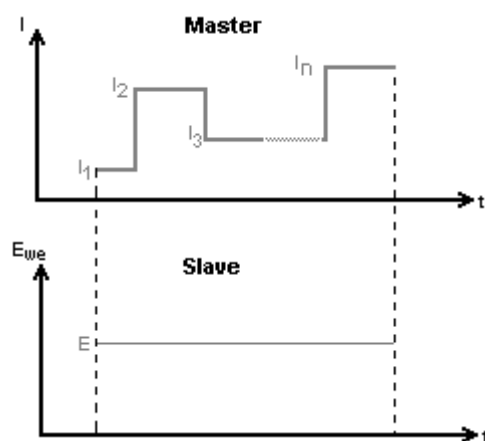


Fig. 98: CP_CA description.

The detailed parameter setup is displayed on the following picture:

The screenshot shows a software interface for setting up an electrochemical experiment. It is titled 'Parameters' and has a 'Description' tab. The main area is divided into two sections: 'CP Master' and 'CA Slave'.
CP Master Section:
 - 'Apply I₁' is set to 0,500 mA, with 'Vs.' set to None.
 - 'for t₁' is set to 0,500 000 sec.
 - There are '+' and '-' buttons and a '1/' button for sequence management.
 - 'Record every dt' is 0,010 00 s.
 - An unchecked checkbox is followed by 'or dE = 0,000 mV'.
 - 'Repeat n_c' is 0 times.
 - 'I Range' is 1 mA, 'E Range' is +/-2.5 V, and 'Bandwidth' is 8.
CA Slave Section:
 - 'Apply E' is 1,000 000 V, with 'Vs.' set to Eref.
 - 'Record every dt' is 0,010 00 s.
 - An unchecked checkbox is followed by 'or dI = 0,000 A'.
 - 'I Range' is 1 A, 'E Range' is +/-2.5 V, and 'Bandwidth' is 8.
 - An 'Update' button is at the bottom right.

Fig. 99: CP_CA detailed setup.

- **CP block**

Experiment parameters

Apply I₁ = pA/nA/./A vs. None/I_{init}

the applied current is defined in absolute or according to the initial current measured at the beginning of the technique. It can be zero if no technique was applied before or it can be the last current value measured in the previous technique.

for t₁ = μs/ms/..../days

fixes the current step duration.

Add sequences

the “+” and “-“ buttons enable the user to add or remove sequences (current steps) to the experiment.

Record I every dt = s (or dE = mV; optional)

The dt condition is applied to both technique of the CP_CA technique. So sampling rate of both techniques are synchronized. If zero is set, all data points will be stored (every 24 μ s).

dE can be selected but if dE is reached only data of the CP channel are recorded.

Repeat $n_c = \dots\dots\dots$ times

runs current sequences for n_c times.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

- **CA block**

Experiment parameters

Apply E = V vs. E_{ref} , E_{oc} , E_{init}

the applied potential is defined in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was previously applied, or it can be the last potential value measured in the previous technique.

Record I every dt = s (or dl = pA/.../A; optional)

The dt condition is the dt set in the CP block.

dl can be selected but if dl is reached only data of the CA channel is recorded.

Instruments parameters

I Range =

enables the user to select the current range.

E Range =

enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

10.3 CA_CA : CA synchronized with CA

The technique is composed of two CA one on the “master” channel and another of the other channel. Both protocols are displayed in the same technique.

The detailed flow diagram is made as follows:

First CA block:

- potential step,
- potential sequences,
- recording conditions,
- repeat option,
- instrument parameters configuration.

Second CA block:

- potential step,
- potential sequences,
- recording conditions,
- instrument parameters configuration.

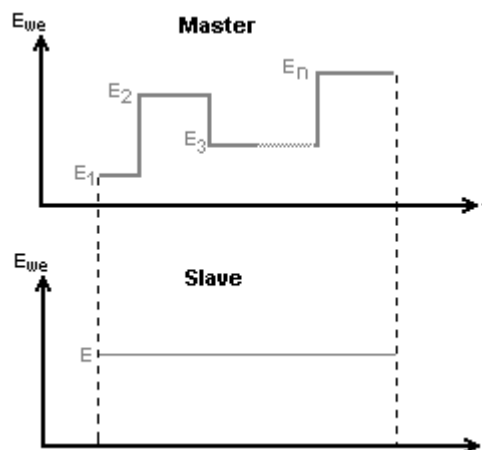


Fig. 100: CA_CA description.

The detailed parameter setup is displayed on the following picture:

Parameters
Description

CA Master ⤴

Apply $E_1 = 1,000\,000$ V Vs. Eref ⌵

for $t_1 = 0,500\,000$ sec ⌵

+ - 1/

Record every $dt = 0,010\,00$ s

or $dI = 0,000$ A ⌵

Repeat $n_c = 0$ times

E Range = ● +/-2.5V ⌵

Bandwidth = ● 8 ⌵

CA Slave ⤴

Apply $E = 1,000\,000$ V Vs. Eref ⌵

Record every $dt = 0,010\,00$ s

or $dI = 0,000$ A ⌵

I Range = ● Auto range ⌵

E Range = ● +/-2.5V ⌵

Bandwidth = ● 8 ⌵

Update

Fig. 101: CA_CA technique

101

- **First CA block:**

Experiment parameters

Apply $E_1 = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

the applied potential is defined in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was previously applied, or it can be the last potential value measured in the previous technique.

for $t_1 = \dots\dots\dots \mu s/ms/.../days$

fixes the potential step duration.

Add sequences

the “+” and “-” buttons enable the user to add or remove sequences (potential steps) to the experiment.

Record I every $dt = \dots s$ (or $dl = \dots pA/.../A$ optional)

The dt condition is applied to both technique of the CA_CA technique. So sampling rate of both techniques are synchronized. If zero is set, all data points will be stored (every 24 μs). dl can be selected but if dl is reached only data of the first CA channel are recorded.

Repeat option for cycling

Repeat $n_c = \dots\dots\dots$ times

runs potential steps sequences for n_c times

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range = $\dots\dots\dots$

enables the user to select the control potential range.

Bandwidth = $\dots\dots\dots$

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

- **Second CA block:**

Experiment parameters

Apply $E = \dots\dots\dots V$ vs. E_{ref} , E_{oc} , E_{init}

the potential is defined in absolute (vs. your reference electrode potential in the cell) or according to the open circuit potential (E_{oc}) or according to the initial potential measured at the beginning of the technique. It can be E_{oc} if no technique was previously applied, or it can be the last potential value measured in the previous technique.

Record I every $dt = \dots s$ (or $dl = \dots pA/.../A$)

The dt condition is the dt set in the first CA block.

dl can be selected but if dl is reached only data of the second CA channel are recorded.

Instruments parameters

I Range = $\dots\dots\dots$

enables the user to select the current range.

E Range =

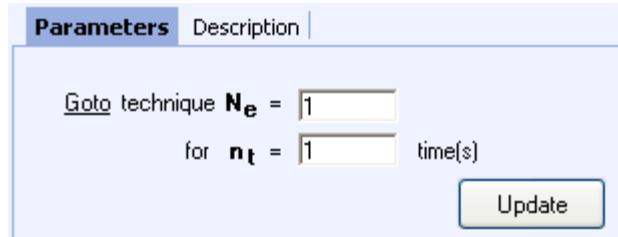
enables the user to select the control potential range.

Bandwidth =

enables the user to select the bandwidth (damping factor) of the potentiostat regulation.

11. Loop option

The loop option has been designed to create experiments with linked techniques. This technique can be loaded only when another technique has been loaded before.



The screenshot shows a dialog box with two tabs: "Parameters" (selected) and "Description". The "Parameters" tab contains the following text and input fields:

Goto technique **N_e** =
for **n_t** = time(s)

An "Update" button is located at the bottom right of the dialog box.

Fig. 102: Loop.

This option goes back to a previous technique of the experiment and enables the user to repeat a sequence of linked techniques several times

12. Combined techniques:

EC-Lab® Express offers the possibility to build easily a linked technique using up to 20 techniques available in EC-Lab Express.

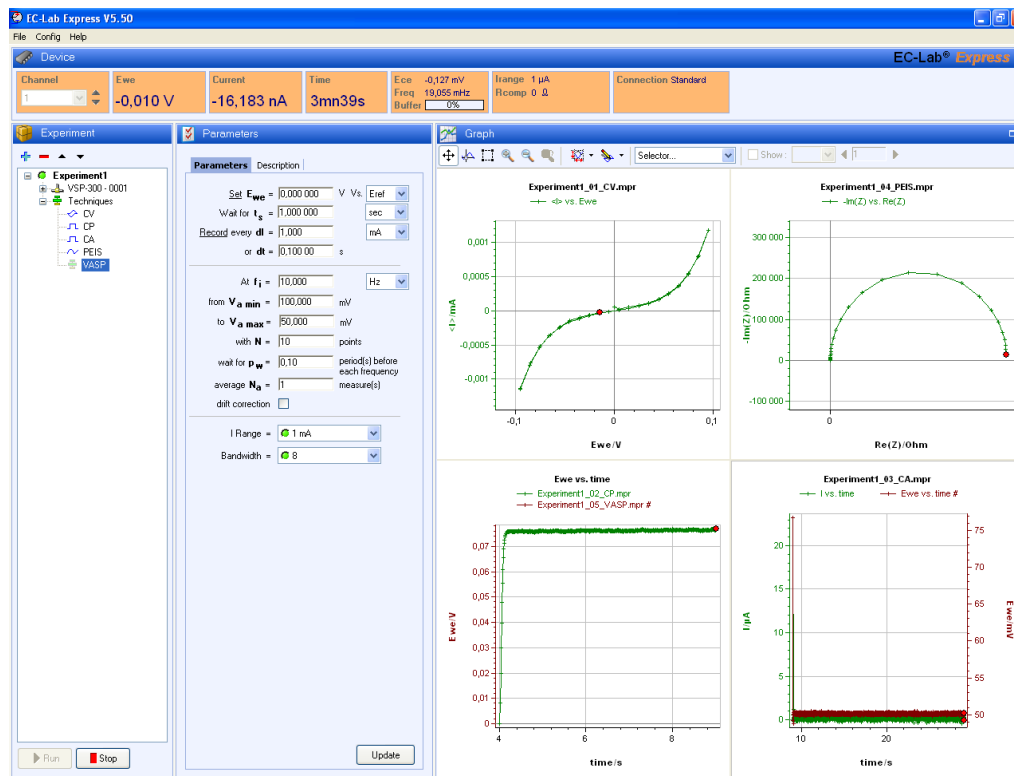


Fig. 103: Linked techniques.

13. Minimum acquisition time calculation

The purpose of this paragraph is to give the EC-Lab[®] Express user a method for calculating the minimum acquisition time.

Each technique in EC-Lab[®] Express allows one or more option such as average calculation, Ultra low current option, Analog In option,... Each technique has its own minimum data acquisition. Adding an option to a technique increases the minimum acquisition time during an experiment and can slow down the experiment. Here after the additional acquisition time to add to the minimum basic time acquisition time of each technique:

Average: 5 μ s

Automatic current range: 5 μ s

ULC option: 10 μ s

Additional recording option: Ece, Analog IN1, Analog IN2, Control, Charge, I range

For each one of these options an additional 5 μ s duration is added to the minimum basic time acquisition for the first option. The addition of a second option increases the duration of the acquisition time by 0.5 μ s. Hereafter an example of calculation

Ece recording alone: 5 μ s

Ece recording +Analog IN1+automatic current range: 6 μ s.

When an odd number of recording option to the first option the minimum time acquisition is upper bounded by the enteger value.

Ece recording +Analog IN1+automatic current range+power recording : 7 μ s.

The tables below show the minimum acquisition time for all techniques available in EC-Lab[®] Express.

		Technology	SP-300	VMP3
Voltamperometric techniques	OCV	Standard (μ s)	20	20
		Fast (μ s)	12	X
	CV	Standard(μ s)	45	50
		Linear(μ s)	1	15
	CA	Standard(μ s)	21	24
		Advanced(μ s)	34	40
		Fast(μ s)	14	X
	CP	Standard(μ s)	21	24
		Advanced(μ s)	34	40
		Fast(μ s)	14	X
	PDYN	Standard(μ s)	50	50
		Advanced(μ s)	60	60
	GDYN	Standard(μ s)	50	50
		Advanced(μ s)	60	60
	LASV	LASV(μ s)	50	50
MOD	MP(μ s)	100	100	

Fig. 104: Minimum acquisition time for voltamperometric techniques

	Technology	SP-300	VMP3
EIS techniques	PEIS(μ s)	24	24
	GEIS(μ s)	24	24
	SPEIS(μ s)	24	24
	SGEIS(μ s)	24	24
Pulsed techniques	DPV(μ s)	40	40
	SWV(μ s)	40	40
	NPV(μ s)	40	40
	RNPV(μ s)	40	40
	DNPV(μ s)	40	40
	DPA(μ s)	40	40
Stack techniques	Stack PDYN(μ s)	X	40 – 40
	Stack GDYN(μ s)	X	50 – 50
	Stack PEIS(μ s)	X	24 – 24
	Stack GEIS(μ s)	X	24 – 24

Fig. 105: Minimum acquisition time for EIS, pulsed and stack techniques

	Technology	SP-300	VMP3
Corrosion techniques	EVT(μ s)	20	20
	LP(μ s)	40	40
	GC(μ s)	40	40
	CPP(μ s)	44	100
	PDP(μ s)	42	42
	PSP(μ s)	24	24
	ZRA(μ s)	40	40
	CASG(μ s)	50	50
	CASP(μ s)	50	50
	VASP(μ s)	24	50
	Ohmic drop	MIR	20
PZIR		24	24
GZIR		24	24

Fig. 106: Minimum acquisition time corrosion and ohmic drop techniques

	Technology	SP-300	VMP3
Trigger	TI(μ s)	20	20
	TO(μ s)	20	20
	TOS(μ s)	20	20
Bipotentiostat	CVCA(μ s)	45 – 21	50 – 24
	CPCA(μ s)	21 – 21	24 – 24
	CACA(μ s)	21 – 21	24 – 24
MUX	MUX(μ s)	20	20
LOOP	LOOP(μ s)	20	20

Fig. 107: Minimum acquisition time for trigger, bipotentiostat, multiplexer and loop techniques

14. Glossary

This glossary is made for the user to understand most of the terms of EC-Lab[®] Express software and the terms mentioned in the manual. The terms are classified in the alphabetical order.

Absolute value: mathematical function that changes the negative values in positive ones.

Accept: button in EC-Lab[®] Express software that switches to "Modify" when the user clicks on. "Modify" must be displayed to run the experiment.

Bandwidth: represents the frequency of the regulation loop of the potentiostat. It depends on the electrochemical cell impedance. The bandwidths values are going from 1 to 7 with increasing frequency.

CASP: corrosion protocol used to determine the corrosion current and the Tafel coefficients. In this technique, a sinusoidal voltage is applied around a potential (E_i) with a small amplitude (V_a) and a constant low frequency (f_s).

CASG: corrosion technique performed on an electrochemical system by applying a current perturbation at a fixed frequency f_s . The perturbation is performed around an initial current (I_i) with a small amplitude (I_a) and a constant low frequency (f_s).

Channels: each one of the boards corresponding to an independent Potentiostat/galvanostat.

Chronoamperometry/ chronocoulometry: controlled potential technique that consists in stepping the potential of the working electrode from an open circuit potential to another potential E_i where electrochemical reactions occur. The resulting curve is a current-time response. Chronocoulometry is an alternative mode for recording the charged passed as a function of time with current integration.

Chronopotentiometry: controlled current technique where the potential is the variable determined as a function of time during a current step.

Cycle: inside a protocol, this term is used to describe a sequence repeated with time.

Cycle number: processing function that allows the user to display on the graphic one or several cycles chosen in the raw file. The selected cycles are lightened and the others are hidden.

Cyclic potentiodynamic pitting (CPP): corrosion protocol used to evaluate pitting susceptibility and made with a potentiodynamic part and a conditional potentiostatic part which is taken into account if the pitting current is not reached during the potentiodynamic part.

Cyclic voltammetry (CV): this protocol consists in scanning linearly the potential of the working electrode and to measure the current resulting from oxydoreduction reactions. Cyclic voltammetry provides information on redox processes, electron transfer reactions and adsorption processes.

Differential Pulse Voltammetry (DPV): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique consists of pulses superimposed on a potential sweep.

Differential Normal Pulse Voltammetry (DNPV): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique is made of increasing prepulses with time and pulses superimposed on the prepulses.

Differential pulse amperometry (DPA): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique consists in the repetition of a pulse sequences made with a prepulse and a pulse superimposed.

Galvano Electrochemical Impedance Spectroscopy (GEIS): protocol for impedance measurement in a galvanostatic mode.

Generalized corrosion (GC): protocol used to study general corrosion. It consists in half a cycle or a cycle of usual cyclic voltammetry with a digital potential sweep.

I range: current range used in the experiment. It is related to the current resolution.

Impedance: defined by the ratio E/I

IR compensation: in the electrochemical cell, the resistance between the working and the reference electrode produces a potential drop that keep the working electrode from being at the controlled potential. IR compensation allows the user to set a resistance value to compensate the solution resistance.

Linear polarization (LP): protocol that consists in a potential ramp around the corrosion potential. It is often used to determine polarization resistance and corrosion current.

Linked experiments: EC-Lab[®] Express offers the ability to link up to ten different experiments with the protocol linker.

Linked experiment settings: the user can save the settings of linked experiments as a .mpls file. This allows the user to load easily all the experiment settings.

Loop: protocol available in the linked experiments and used to repeat one or more experiments. It is different from the cycle in an experiment.

Potentiodynamic pitting (PDP): corrosion protocol designed to study pitting corrosion on one electrode in the electrochemical cell. This protocol corresponds to the pitting potential determination of a material using a potential sweep.

Potentiostatic pitting (PSP): corrosion protocol designed to study pitting corrosion on one electrode in the electrochemical cell using a potential step.

Normal pulse voltammetry (NPV): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique is made of increasing pulses with time that are always coming back to the beginning potential.

Open Circuit Voltage (OCV): protocol that consists in a period during which no potential or current is applied to the working electrode. The cell is disconnected and only the potential measurement is available.

Pause: Button of EC-Lab[®] Express main window that lead to a suspension in the progress of the protocol and in the measurement recording. The cell is disconnected (OCV period). The "Pause" button switches to "Resume" when clicked.

Potentiostatic impedance (PEIS): protocol that performs impedance measurements into potentiostatic mode in applying a sinus around a potential E that can be set to fixed value or relatively to the cell equilibrium potential.

Reverse Normal Pulse Voltammetry (RNPV): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique is made of increasing pulses with time that are always coming back to the beginning potential. The current is sampled in the opposite way as for the NPV technique.

Run: button that start the experiment.

Scan rate: speed of the potential sweep defined with the smallest possible step amplitude

Triggers: option that allows the instrument to set a trigger out (TTL signal) at experiment start/stop or to wait for an external trigger in to start or stop the run.

Square Wave Voltammetry (SWV): protocol used in analytical electrochemistry to discriminate faradic from capacitive current. This technique is made of successive positive and negative pulses according to the averaged potential sweep.

VASP: Variable Amplitude Sinusoidal micro Polarization is a corrosion technique allowing the determination of the corrosion current and the Tafel parameters. This technique is performed by applying a sinusoidal potential wave around the corrosion potential with N amplitudes increasing from Vamin to Vamax. For each amplitude, the polarization resistance (Rp) is determined and Rp versus applied potential amplitude is plotted

Zero Resistance Ammeter (ZRA): protocol used to perform measurements to examine the effects of coupling dissimilar metals or to perform some types of electrochemical noise measurements.

15. Acronyms list

CA: ChronoAmperometry

CA Adv: ChronoAmperometry advanced

CP: ChronoPotentiometry

CP Adv: ChronoPotentiometry advanced

CPP: Cyclic Potentiodynamic Pitting

CASG: Constant Amplitude sinusoidal micro-Galvanopolarization

CASP: Constant Amplitude Sinusoidal microPolarization

CV: Cyclic Voltammetry

CV Adv: Cyclic Voltammetry Advanced

DNPV: Differential Normal Pulse Voltammetry

DPA: Differential Pulse Amperometry

DPV: Differential Pulse Voltammetry

EVT: Ecorr Versus Time

GC: Generalized Corrosion

GDyn: GalvanoDynamic

GDyn Adv: GalvanoDynamic Advanced

GEIS: Galvanostatic Impedance

GZIR: IR determination with Galvanostatic Impedance

LASV: Large Amplitude Sinusoidal Voltammetry

LP: Linear Polarization

MIR: Manual IR

NPV: Normal Pulse voltammetry

OCV: Open Circuit Voltage

PDP: PotentioDynamic Pitting

PDyn: PotentioDynamic

PDyn Adv: PotentioDynamic Advanced

PEIS Potentiostatic Impedance

PSP: Potentiostatic Pitting

PZIR: IR determination with Potentiostatic Impedance

RNPV: Reverse Normal Pulse Voltammetry

SGEIS: Staircase Galvano Electrochemical Impedance Spectroscopy

SPEIS: Staircase Potentio Electrochemical Impedance Spectroscopy

SWV: Square Wave Voltammetry

TI: Trigger In

TO: Trigger Out

TOS: Trigger Set

VASP: Variable Amplitude Sinusoidal micro Polarization

ZRA: Zero Resistance Ammeter

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